

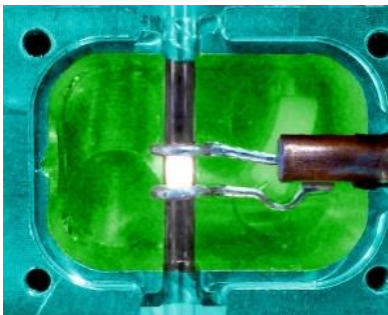


Online Low Temperature Plasma Seminar

July 2021

Multiple phases: charged droplets, colloids and solids in a low temperature atmospheric pressure plasma

Paul Maguire
Ulster University





- Some multiple phase examples and applications
- Liquid droplet in plasma
- Droplet charge
- Electron flux to particle



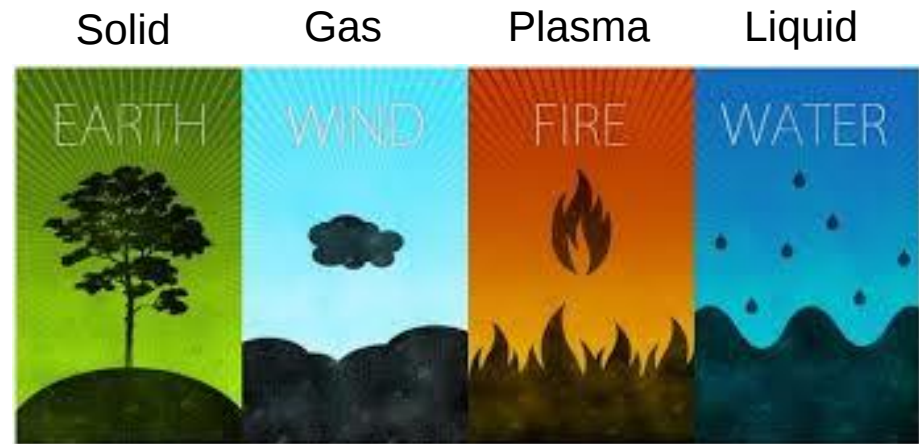
- The **elements** of the ancients

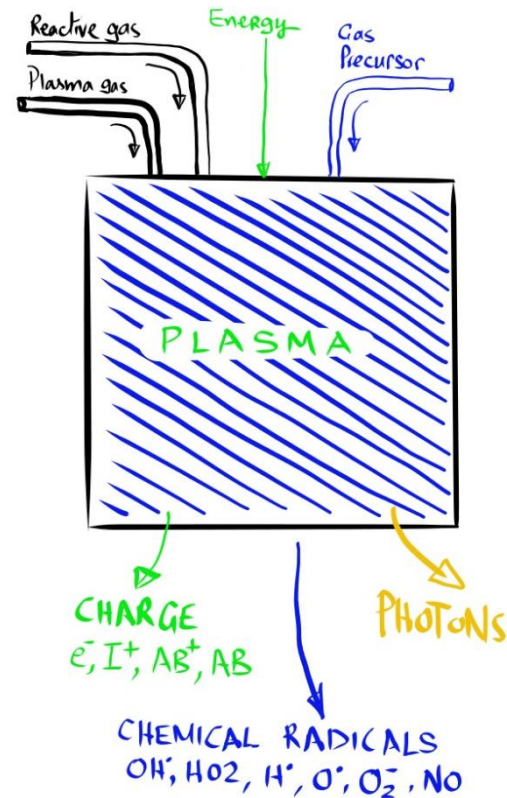
- ⇒ *In no particular order*
- ⇒ Earth: Wind: Fire: Water:

- Multiphase systems

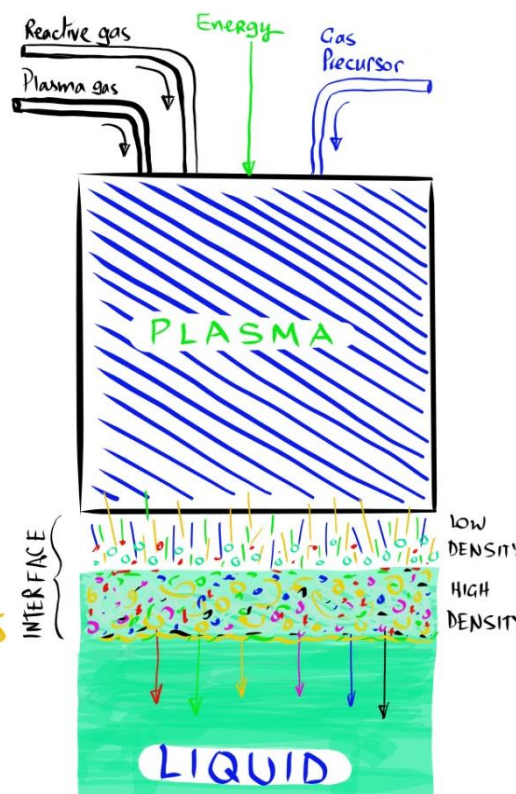
- ⇒ Combining
- ⇒ Multiphase flow
- ⇒ Non-equilibrium Plasmas
- ⇒ **Solid : Gas : Plasma : Liquid**

- Bringing low temperature plasmas to the Gas-Liquid interface





Plasma species & neutral gas molecules, produce energetic charged ions, electrons, photons and radicals



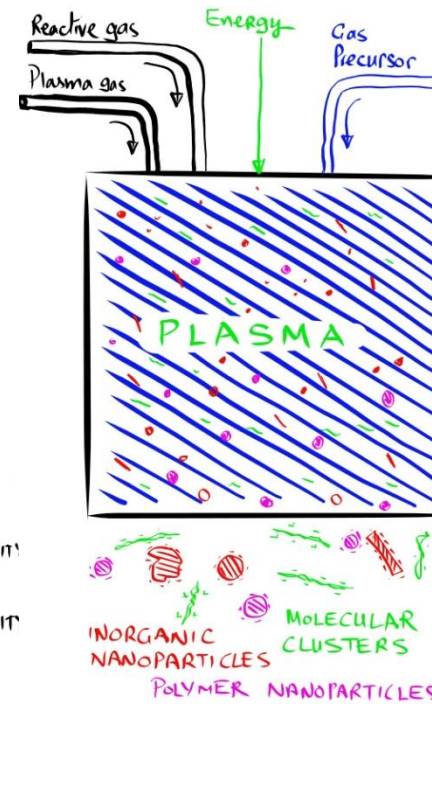
Plasma species & neutral gas molecules, produce energetic charged ions, electrons, photons and radicals.

Transferred to liquid.

Transition region:

- low density layer
- High density layer

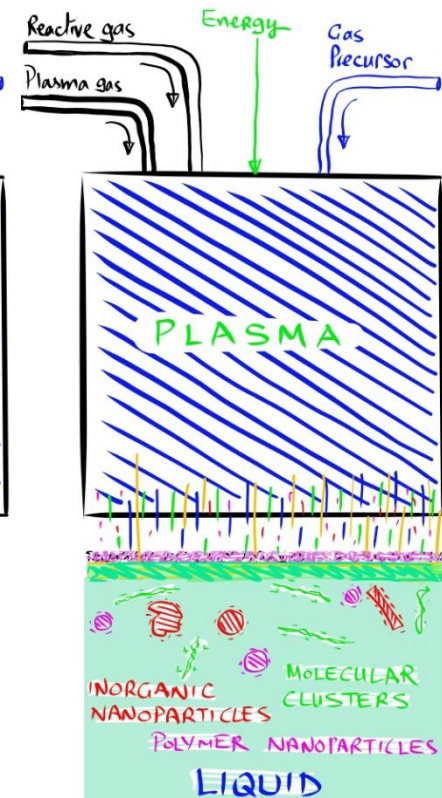
Equilibrium region



Plasma species & neutral gas molecules, produce energetic charged ions, electrons, photons and radicals.

Gas precursors also create

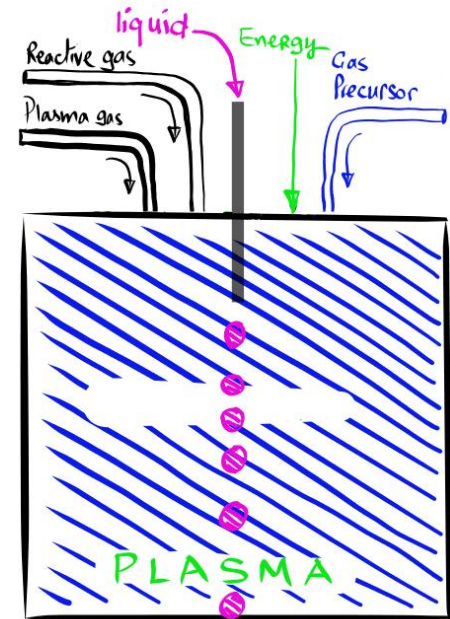
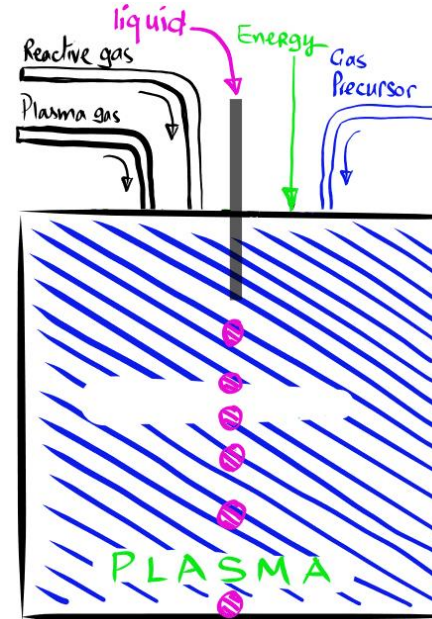
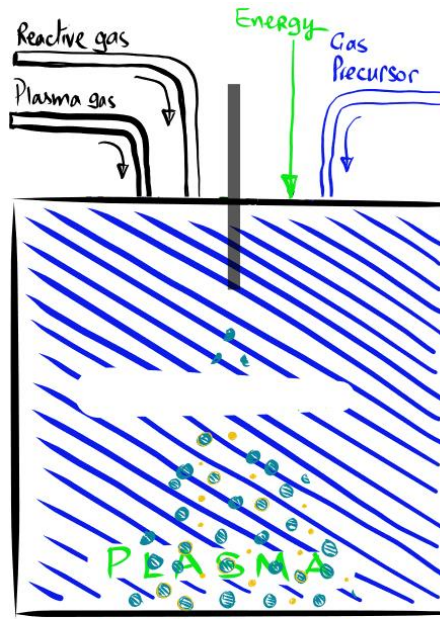
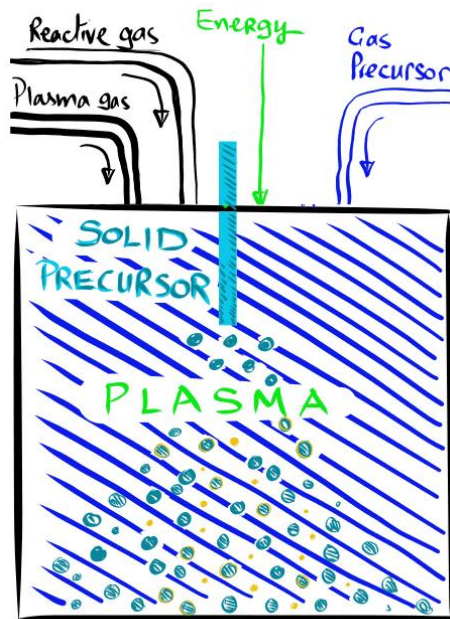
- molecular clusters
- solid particles



Plasma species & neutral gas molecules, produce energetic charged ions, electrons, photons and radicals.

Transferred to liquid.

Reactions create solid particles



clusters & nanoparticles.
Solid, liquid & solid-core &
liquid surface.

Plasma species &
neutral gas molecules,
produce energetic
charged ions, electrons,
photons and radicals.

Solid precursors create

- molecular clusters
- solid particles
- liquid – solid particles

Precursors create

- molecular clusters
- solid particles
- liquid – solid particles

Transfer to polymer
liquid, hydrogels etc to
form nanocomposite

Aerosol Microdroplets

Plasma & neutral gas
molecules, produce
charged ions, electrons,
photons & radicals.
Transferred to liquid drop
inside plasma.

Activated droplet
Transported far from
plasma

Liquid Microdroplets

With solid nanoparticles
Plasma, neutral molecules,
produce ions, electrons,
photons & radicals.

Transferred to liquid drop
with liquid precursor
Nanoparticle synthesis
Transported far from
plasma



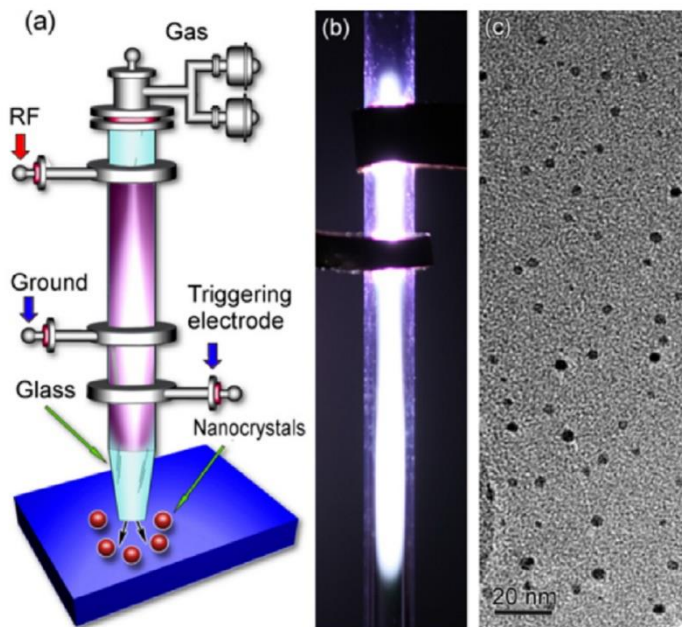
Nanoparticle Synthesis

Plasma charging and heating of particles



- Plasma interactions

- ⇒ SiH_4 monomer dissociation by plasma
- ⇒ Molecular assembly → cluster formation
- ⇒ Particle assembly
- ⇒ Solid surface irradiation by charge & radicals
- ⇒ Surface temperature elevation and melting
- ⇒ Rapid local annealing and quenching



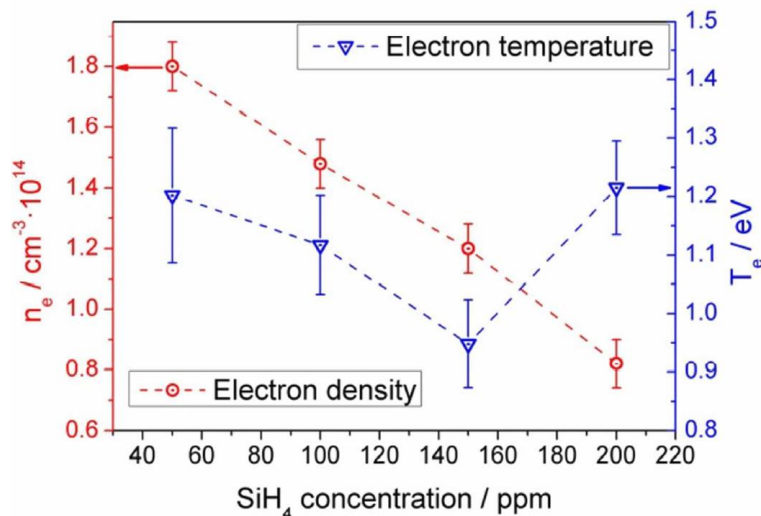
ADVANCED MATERIALS

The Interplay of Quantum Confinement and Hydrogenation in **Amorphous Silicon** Quantum Dots, Askari et al., 2015 10.1002/adma.201503013



- Plasma interactions

- SiH₄ monomer dissociation
- Cluster formation
- Solid surface irradiation by charge & radicals
- Surface temperature elevation and melting
- Rapid local annealing and quenching

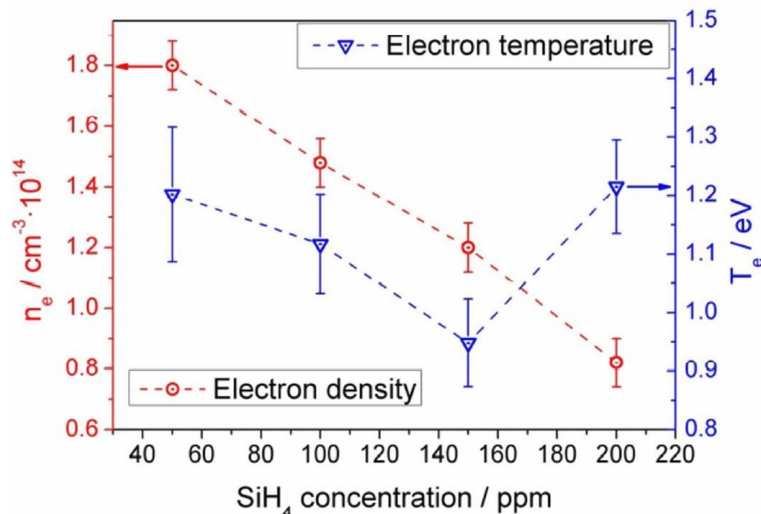


Electron density (left axis) and electron temperature (right axis) calculated



• Plasma interactions

- ⇒ SiH_4 monomer dissociation
- ⇒ Cluster formation
- ⇒ Solid surface irradiation by charge & radicals
- ⇒ Surface temperature elevation and melting
- ⇒ Rapid local annealing and quenching



Electron density (left axis) and electron temperature (right axis) calculated

• Hot nanoparticles – Cold gas

- ⇒ Tailored semiconductor properties
- ⇒ Liquid phase present?
- ⇒ Facilitates mass transfer gas → solid ?

• Charge collisional model

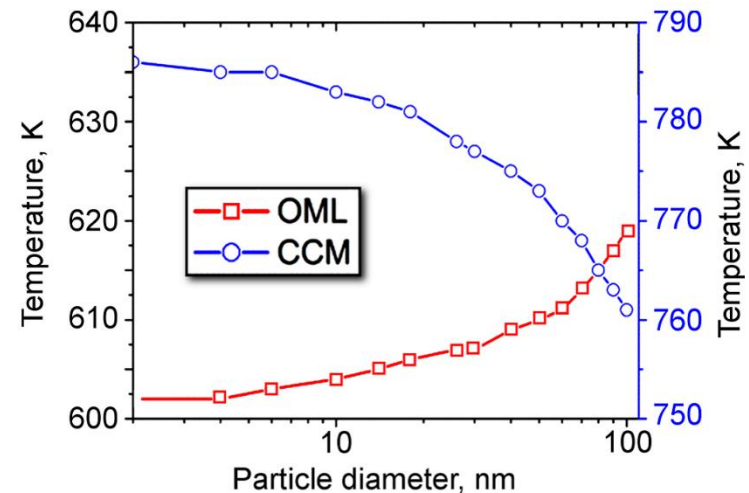


FIG. 4. Particle temperature for a range of nanoparticle diameter according to the two theoretical frameworks, OML, and CCM.

Crystalline Si nanoparticles below crystallization threshold: Effects of collisional heating in non-thermal atmospheric-pressure microplasmas

S. Askari, I. Levchenko, K. Ostrikov, P. Maguire, and D. Mariotti

Citation: *Applied Physics Letters* **104**, 163103 (2014); doi: 10.1063/1.4872254

View online: <http://dx.doi.org/10.1063/1.4872254>



• Crystallisation

- Amorphous – crystalline temperature contour
- Increase in crystallisation temperature with D
- Charge flux – size dependent
- Local surface heating – local melting?
- Facilitates mass transfer from gas/plasma to solid state

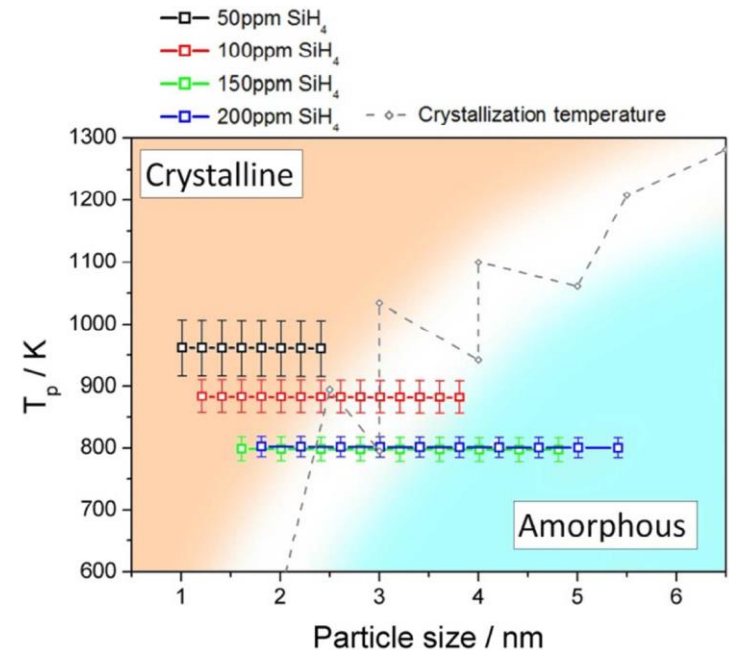


Figure 4. Particle temperature calculated using the collision-corrected model (CCM)

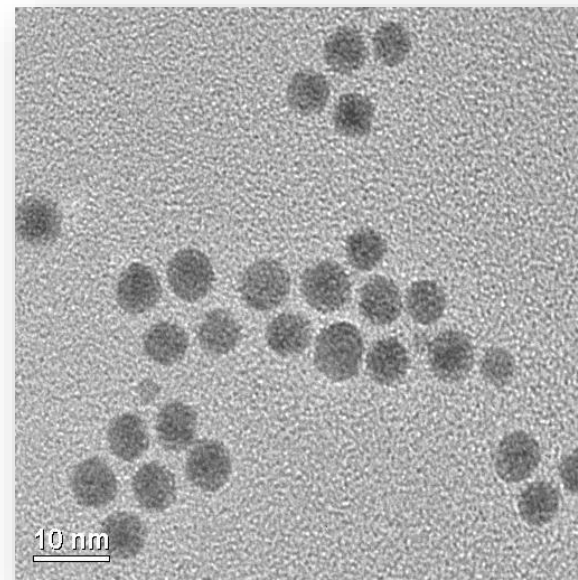


• Controlling crystal structure:

- Ultra-small Sn nanocrystals - from non-equilibrium plasma at atmospheric pressures.
- Larger nanocrystals adopt the β -Sn tetragonal structure,
- Smaller nanocrystals ($< 2\text{nm}$) show stable α -Sn diamond cubic structure.
- Nanocrystals in the range 2–3 nm, which exhibit mixed phases.
- Understanding structural stability at the nanoscale
- Achieving unique phases for different applications.

• Plasma interactions

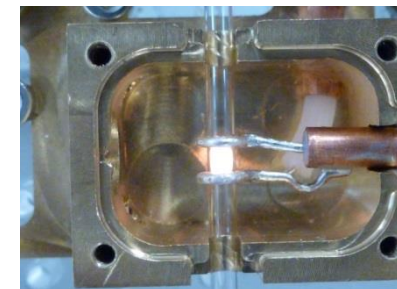
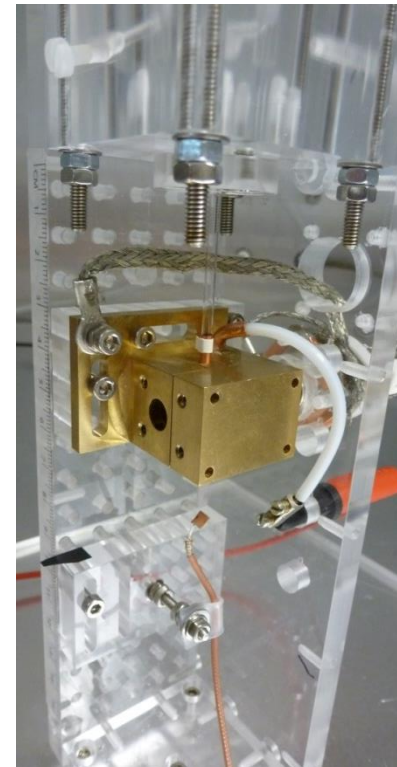
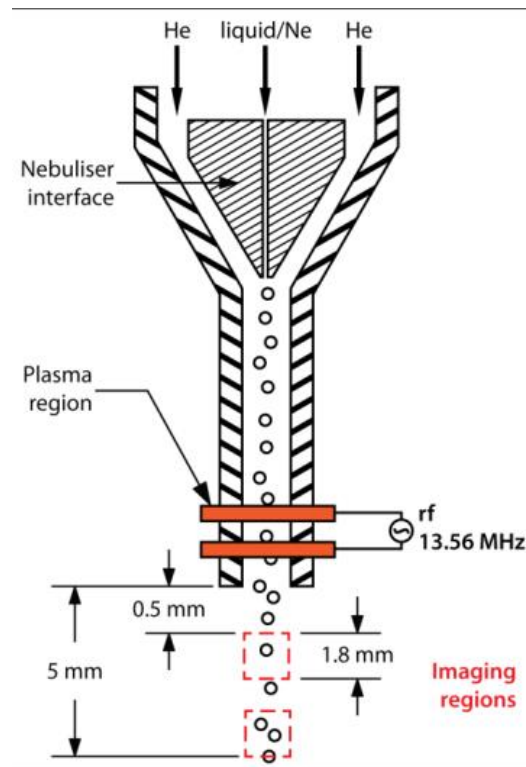
- Solid Sn metal precursor
- Atomic “sputtering” or molten droplet (?)
- High density microplasma $\sim 10^{20} \text{ m}^{-3}$.
- Cluster formation or liquid metal droplet
- Surface irradiation by charge & radicals
- Surface temperature elevation
- Rapid local annealing and quenching





• Plasma - Microdroplets

- ⇒ Stream of microdroplets flows through plasma
- ⇒ Low gas temperature,
- ⇒ “large” size of droplet
- ⇒ short residence
- ⇒ limited evaporation
- ⇒ droplet remains intact



Controlled microdroplet transport in an atmospheric pressure microplasma

P. D. Maguire, C. M. O. Mahony, C. P. Kelsey, A. J. Bingham, E. P. Montgomery, E. D. Bennet, H. E. Potts, D. C. E. Rutherford, D. A. McDowell, D. A. Diver, and D. Mariotti, Appl. Phys. Lett. 106, 224101 (2015), <https://doi.org/10.1063/1.4922034>



Energy and solar

Biomedical

Plasma - medicine

Optical

Thermal

Applications



• Unique High Value Materials

- Atmospheric Pressure Plasma Sources
- Collisional
- Non-thermal equilibrium

• Multiple Phases

- Gas-phase synthesis
- Plasma – cluster
- Plasma – molten solid - solid
- Plasma-bulk liquid
- Plasma-droplet (low evaporation)
- H₂O, ethanol, hydrocarbons, monomers



Continuous In-Flight Synthesis for On-Demand Delivery of Ligand-Free Colloidal Gold Nanoparticles

Paul Maguire¹, David Rutherford¹, Manuel Macias-Montero¹, Charles Mahony¹, Colin Kelsey¹, Mark Tweedie¹, Fátima Pérez-Martín¹, Harold McQuaid¹, Declan Diver¹, and Davide Mariotti²

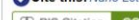
¹ NIBEC, University of Ulster, Belfast, BT37 0QB, Northern Ireland

² SUPA, School of Physics and Astronomy, University of Glasgow, Glasgow G12 8QQ, United Kingdom

Nano Lett., 2017, 17 (3), pp 1336–1343

DOI: 10.1021/acs.nanolett.6b03440

Cite this: Nano Lett., 2017, 17, 3, 1336–1343



Cite This: Nano Lett. 2018, 18, 5681–5687

pubs.

Low-Loss and Tunable Localized Mid-Infrared Plasmons in Nanocrystals of Highly Degenerate InN

Sadegh Askari^{*,†,‡}, Davide Mariotti[‡], Jan Eric Stehr[‡], Jan Benedikt[‡], Julien Keraudy[‡], and Ulf Helmerson[‡]



Haq, A. U. et al Size-dependent stability of ultra-small α - β -phase tin nanocrystals synthesized by microplasma. *Nat. Commun.* 2019, 10 DOI:10.1038/s41467-019-08661-9

PLASMA PROCESSES AND POLYMERS

Feature Article

Plasma–Liquid Interactions at Atmospheric Pressure for Nanomaterials Synthesis and Surface Engineering

Davide Mariotti[✉], Jenish Patel, Vladimír Švrček, Paul Maguire

First published: 06 August 2012 | <https://doi.org/10.1002/ppap.201200007> | Cited by: 81

SCIENTIFIC REPORTS

Article | OPEN | Published: 26 October 2015

Enhanced Dispersion of TiO₂ Nanoparticles in a TiO₂/PEDOT:PSS Hybrid Nanocomposite via Plasma–Liquid Interactions

Yazi Liu, Dan Sun[✉], Sadegh Askari, Jenish Patel, Manuel Macias-Montero, Somak Mitra, Richao Zhang, Wen-Feng Lin, Davide Mariotti & Paul Maguire

Scientific Reports 5, Article number: 15765 (2015) | Download Citation ↓



Article | OPEN | Published: 01 August 2017

Charge carrier localised in zero-dimensional (CH₃NH₃)₃Bi₂I₉ clusters

Chengsheng Ni, Gordon Hedley, Julia Payne, Vladimír Švrček, Calum McDonald, Lethy Krishnan Jagadamma, Paul Edwards, Robert Martin, Gunisha Jain, Darragh Carolan, Davide Mariotti, Paul Maguire, Ifor Samuel & John Irvine[✉]

Green Chemistry



PAPER

View Article Online
View Journal

Check for updates

Cite this: DOI: 10.1039/c8gc03291c

Understanding plasma–ethanol non-equilibrium electrochemistry during the synthesis of metal oxide quantum dots†

Dilli Babu Padmanaban^{*,†,‡}, Ruairi McGlynn[‡], Emily Byrne[‡], Tamilselvan Velusamy[‡], Małgorzata Swadźba-Kwaśny[‡], Paul Maguire[‡] and Davide Mariotti[‡]

ACS APPLIED MATERIALS & INTERFACES

Microplasma Processed Ultrathin Boron Nitride Nanosheets for Polymer Nanocomposites with Enhanced Thermal Transport Performance

Ri-Chao Zhang^{†,‡}, Dan Sun[†], Ai Lu[‡], Sadegh Askari[‡], Manuel Macias-Montero[‡], Paul Joseph[‡], Dorian Dixon[‡], Kostya Ostrikov^{†,‡}, Paul Maguire[‡], and Davide Mariotti[‡]

[†] Department of Chemical and Biological Engineering, Zhejiang University, Hangzhou, 310002, PR China

[‡] School of Mechanical and Aerospace Engineering, Queen's University Belfast, BT9 5AH, U.K.

[‡] Nanotechnology and Integrated Bioengineering Centre (NIBEC), University of Ulster, Newtownabbey, BT37 0QB, Northern Ireland, U.K.

[‡] Institute of Chemical Materials, Chinese Academy of Sciences, Beijing 100029, People's Republic of China



Nano Energy

Volume 50, August 2018, Pages 245–255

<https://doi.org/10.1016/j.nanoen.2018.05.036>

Full paper

Type-I alignment in MAPbI₃ based solar devices with doped-silicon nanocrystals

Conor Rocks^{*,‡}, Vladimír Švrček[‡], Tamilselvan Velusamy[‡], Manuel Macias-Montero[‡], Paul Maguire[‡], Davide Mariotti[‡]



Microplasma-assisted electrochemical synthesis of Co₃O₄ nanoparticles in absolute ethanol for energy applications

Chengsheng Ni^{*,abc}, Darragh Carolan^a, Conor Rocks^a, Jianing Hui^b, Zeguo Fang^b, Dilli Babu Padmanaban^a, Jiupai Ni^c, Deti Xie^c, Paul Maguire^a, John T. S. Irvine^b and Davide Mariotti^a



DOI: 10.1039/C7SE00158D (Paper) *Sustainable Energy Fuels* 2017, 1, 1611–1619

Environmentally friendly nitrogen-doped carbon quantum dots for next generation solar cells†

Darragh Carolan^{*,†,‡}, Conor Rocks[‡], Dilli Babu Padmanaban[‡], Paul Maguire[‡], Vladimír Švrček[‡] and Davide Mariotti[‡]

[†] Nanotechnology & Integrated Bio-Engineering Centre (NIBEC), Ulster University, Jordanstown, Newtownabbey, Co. Antrim BT37 0QB, UK. E-mail: d.carolan@ulster.ac.uk

[‡] Research Centre of Photovoltaics, National Institute of Advanced Industrial Science and Technology-AIST, Central 2, Tsukuba, Japan

ADVANCED MATERIALS

Communication | Open Access

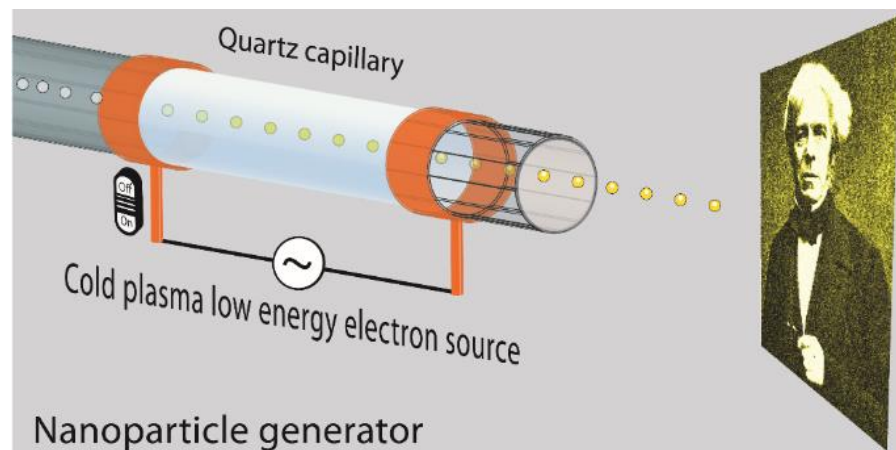
The Interplay of Quantum Confinement and Hydrogenation in Amorphous Silicon Quantum Dots

Sadegh Askari[✉], Vladimír Švrček, Paul Maguire, Davide Mariotti[✉]

First published: 02 November 2015 | <https://doi.org/10.1002/adma.201503013> | Cited by: 12



- Solids formed in liquids in gas/plasma

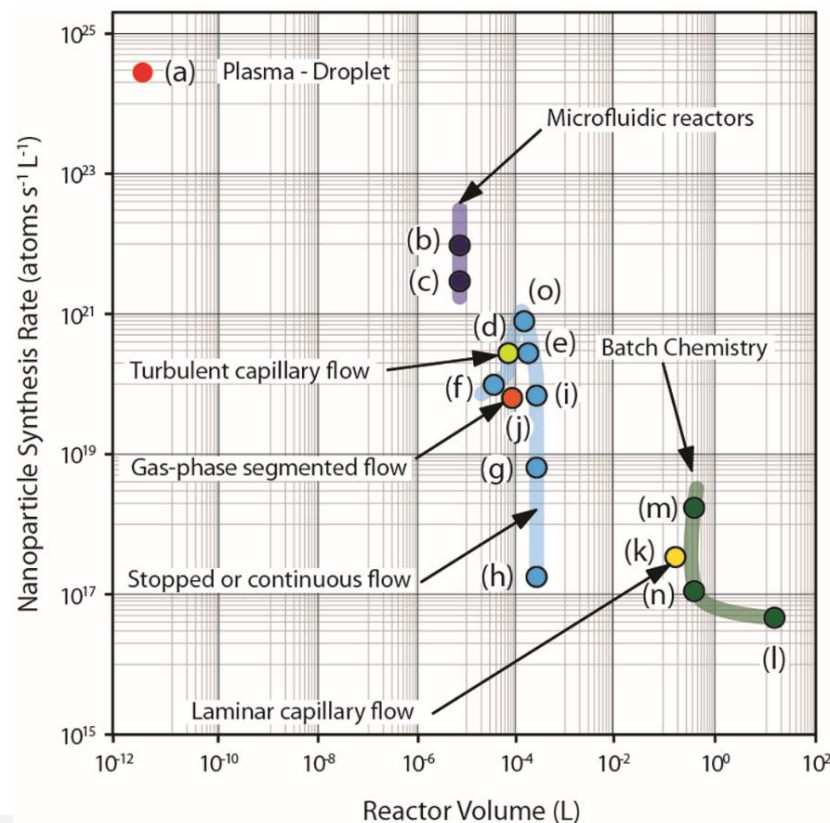
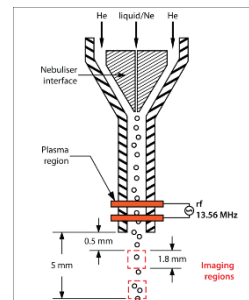


- Nanoparticles: on demand delivery

- HAuCl₄ in H₂O microdroplet
- Passed through plasma
- 120 us time of flight

- Electron flux

- Direct reduction of Au³⁺ ions in liquid by solvated electrons from plasma



Comparison of plasma – droplet synthesis rate with batch and microreaction chemistry



- $\times 10^3 - 10^7$ faster

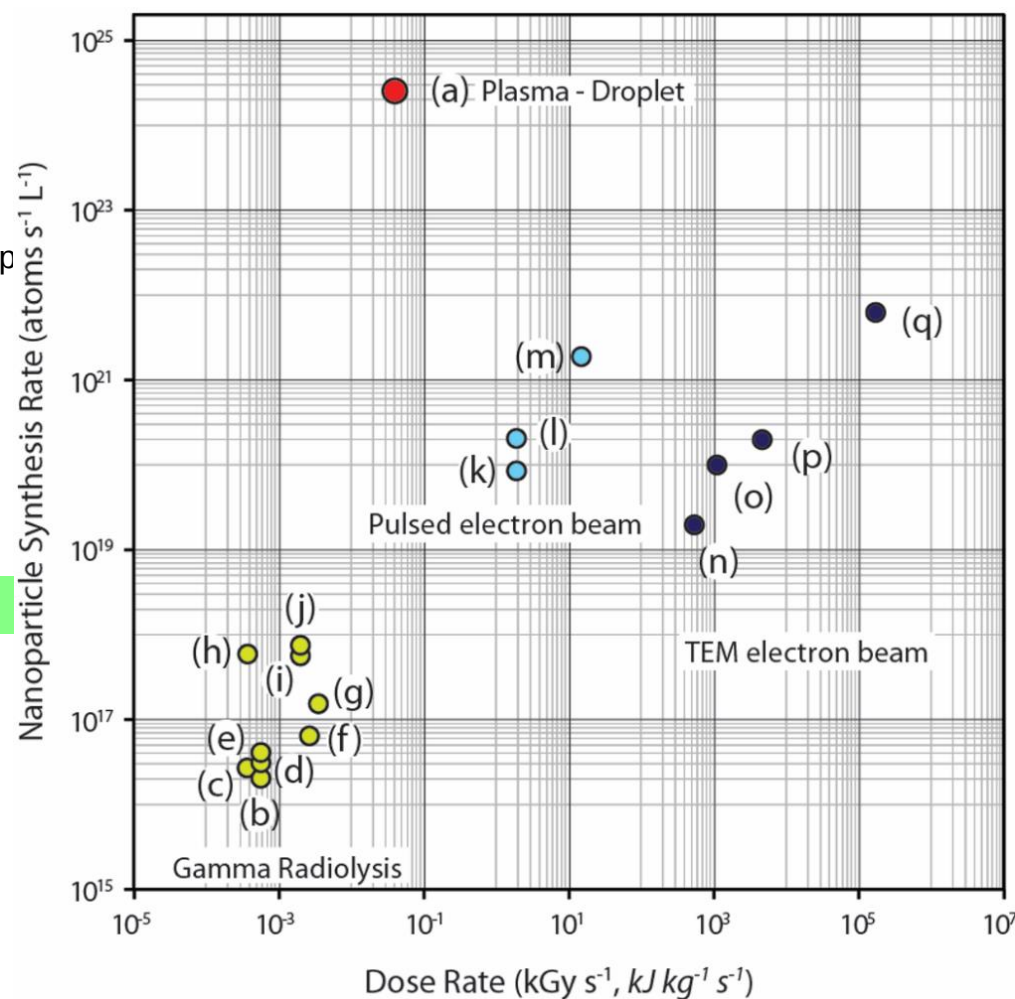
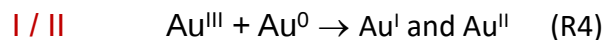
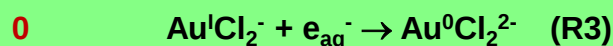
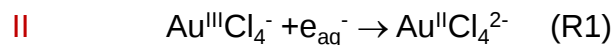
⇒ Similar dose rate as gamma radiation

- Plasma-droplet

⇒ Dose rate assuming $x\%$ plasma energy delivered to drop

⇒ $5 \times 10^{-2} \text{ kGy s}^{-1}$.

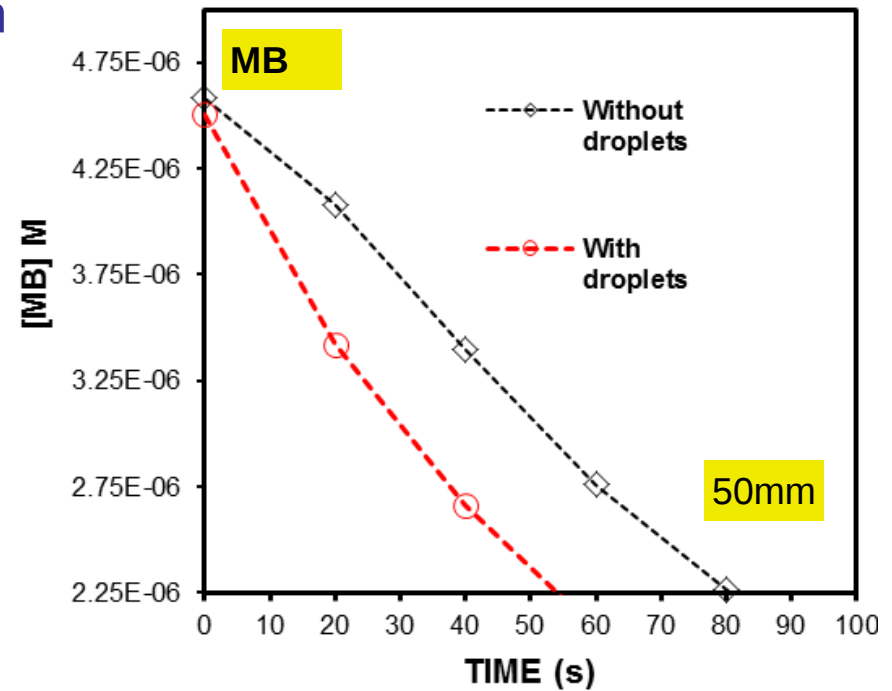
HAuCl_4 . The reduction of Au^{III} proceeds via reactions as:

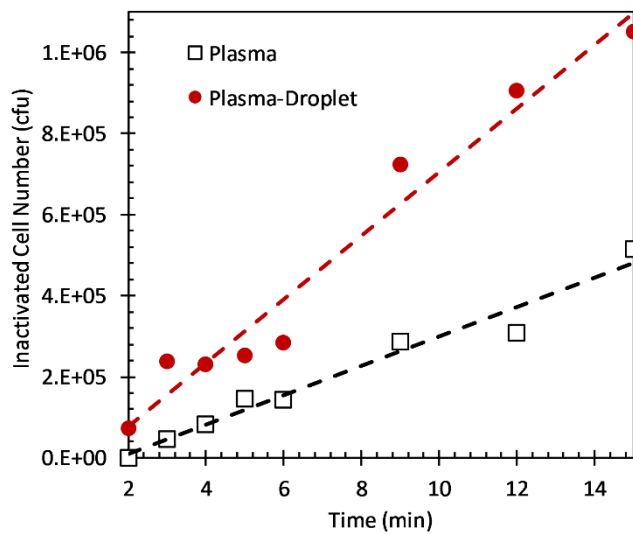


Comparison of plasma – droplet synthesis rate with high energy radiolysis or electron beam methods

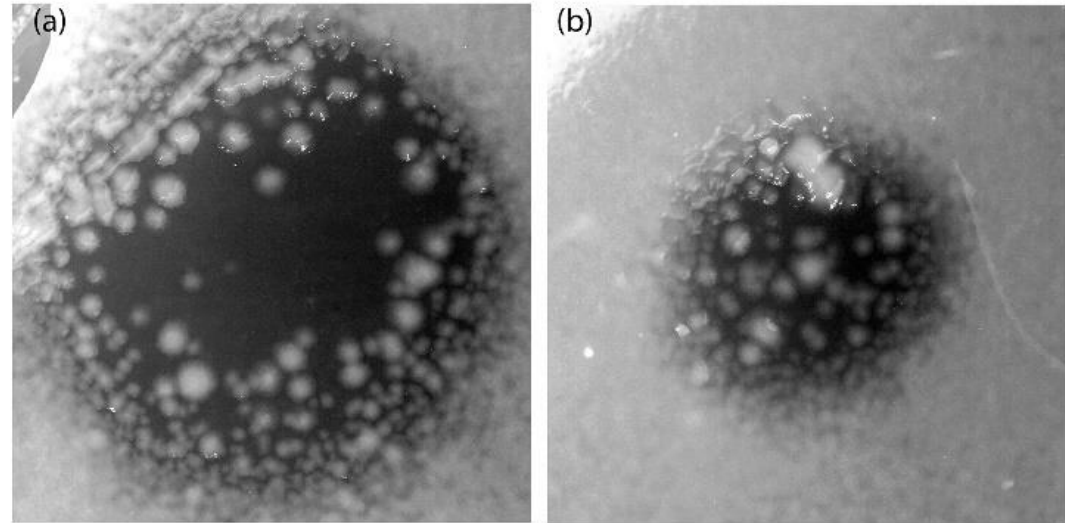


- Methylene Blue indicator destruction
- Significant increase in OH delivered using microdroplets

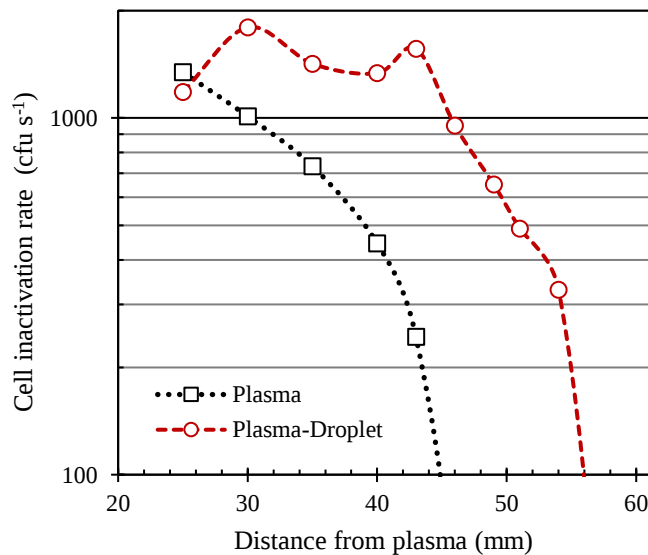




No of cells inactivated versus PE and PED exposure time at a fixed distance of 4.3 cm, calculated from ZoI diameter assuming $\sim 4000 \text{ cfu mm}^{-2}$.



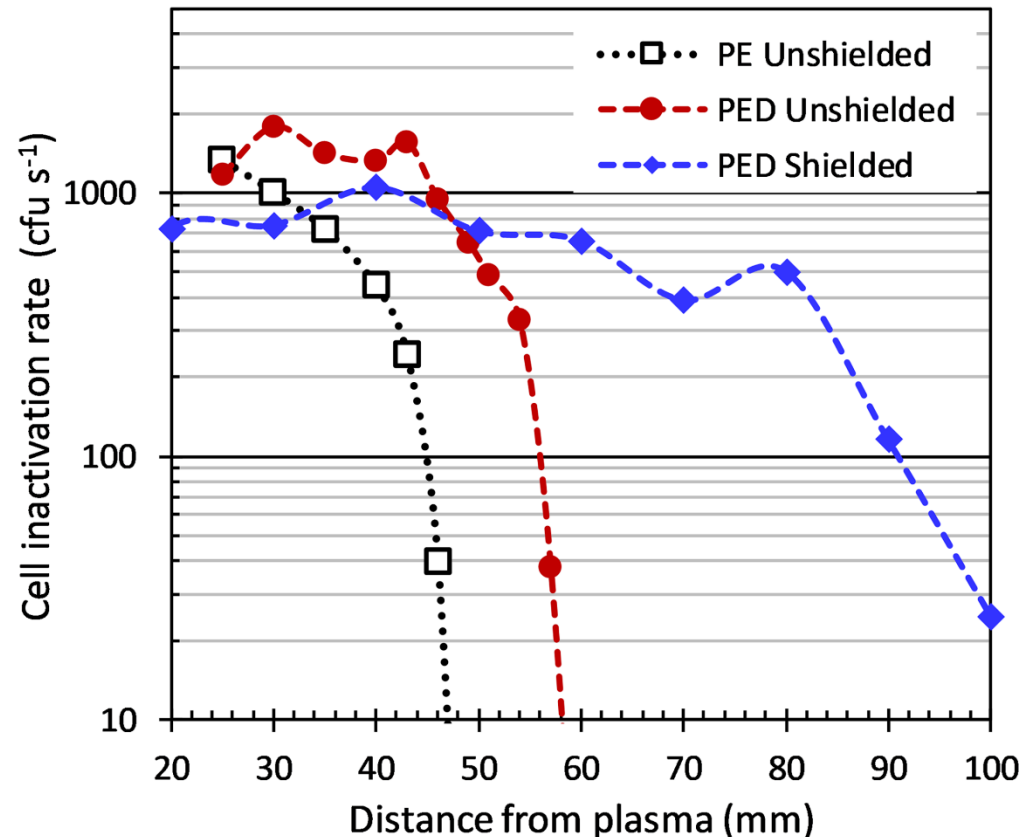
E coli growth inhibition zone (ZoI) at a distance of 40 mm from plasma, after 3 min exposure to (a) plasma effluent with **droplets** and (b) plasma effluent



Increased efficacy in killing E coli with distance using droplets



- Cell inactivation rate vs distance from plasma
- Plasma only (black)
 - ⇒ RF plasma
 - ⇒ Plasma – free effluent a few millimetres beyond electrode
 - ⇒ No ionization waves / bullets
 - ⇒ Inactivation efficacy determined by reach of effluent
- Plasma + Droplets (red)
 - ⇒ Open air delivery
 - ⇒ Efficacy extends to larger distances
 - ⇒ Extra is due to droplet reactivity
- Plasma + Droplets in a flexible tube (blue)
 - ⇒ Shielded delivery
 - ⇒ Droplets shielded from turbulence at plasma exit
 - ⇒ Inactivation efficacy extends further
 - ⇒ Extra is due to droplet reactivity
 - ⇒ Possible limits of reactive species lifetime
- Plasma exposed droplets: increased efficacy in killing E coli over larger distances



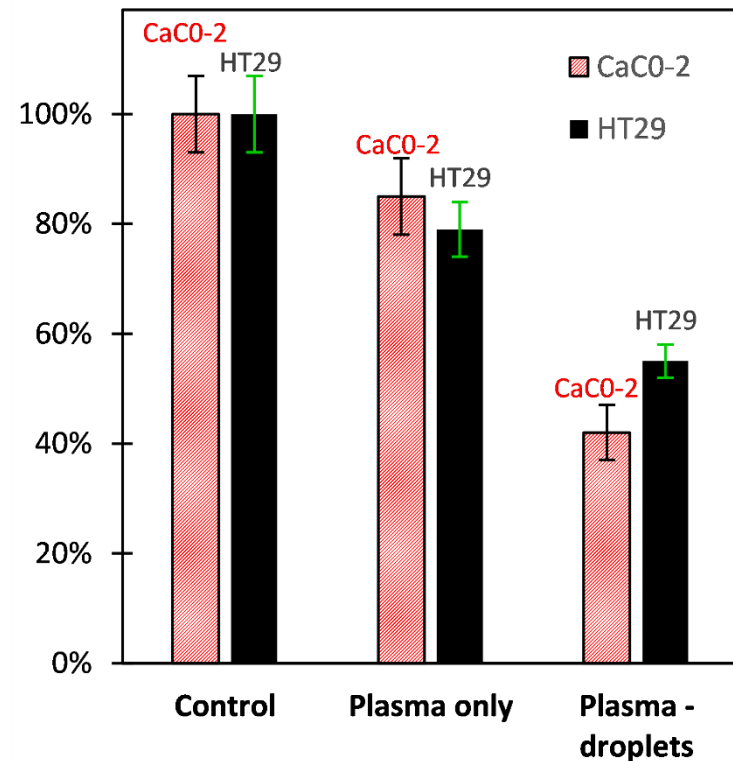


- Tumour cells

- ⇒ In-vitro
- ⇒ Colorectal tumour cells: HT29, CaC0-2
- ⇒ 3 min exposure to droplets, fixed distance
- ⇒ 24h culture

- Cell viability

- ⇒ Significant reduction in cell viability after short exposure due to reactive droplets





• L-Cysteine loaded microdroplets

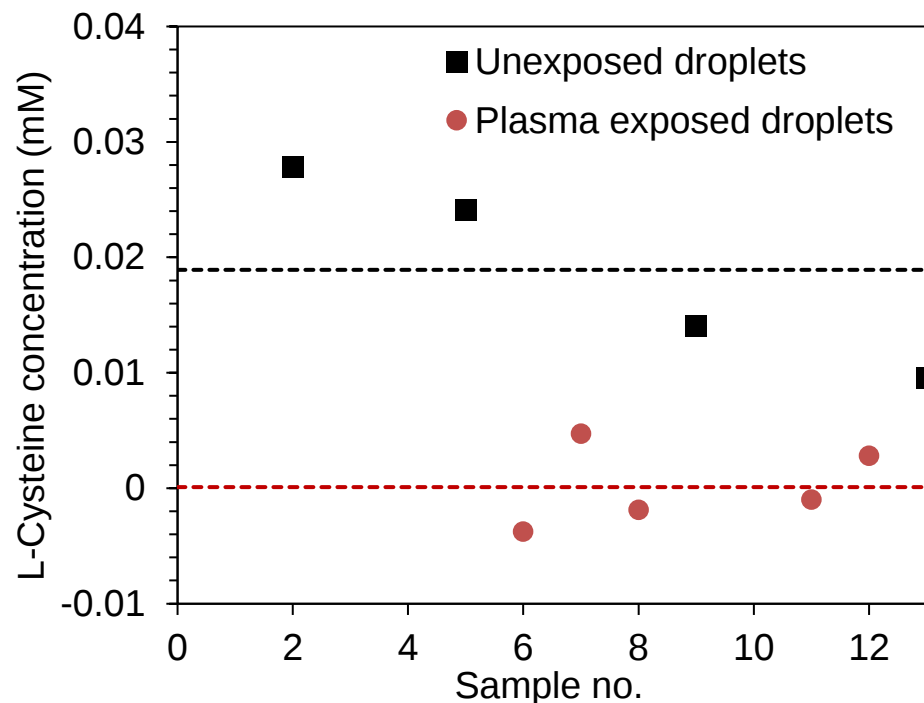
- Limit of detection
- 100 mM (x 100 higher)
- 250 us plasma exposure
- 99.5% conversion
- IPA scavenging prevents most of conversion

Plasma – liquid reaction rate = $3 \times 10^{-6} \text{ M s}^{-1}$

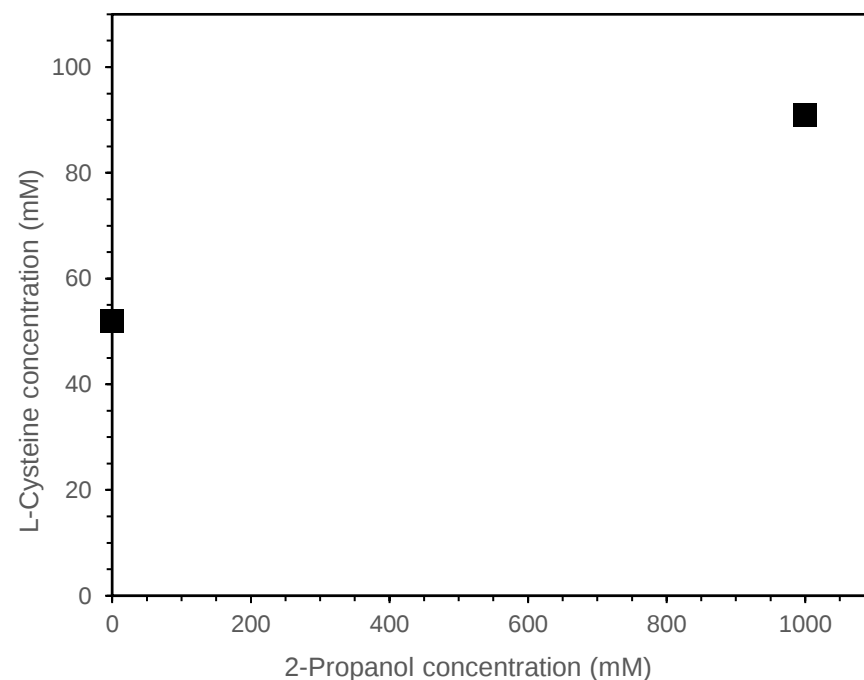
Plasma – droplet reaction rate = 400 M s^{-1}

8 orders of magnitude increase

L-Cysteine loaded (100 mM) microdroplets



L-Cysteine with IPA





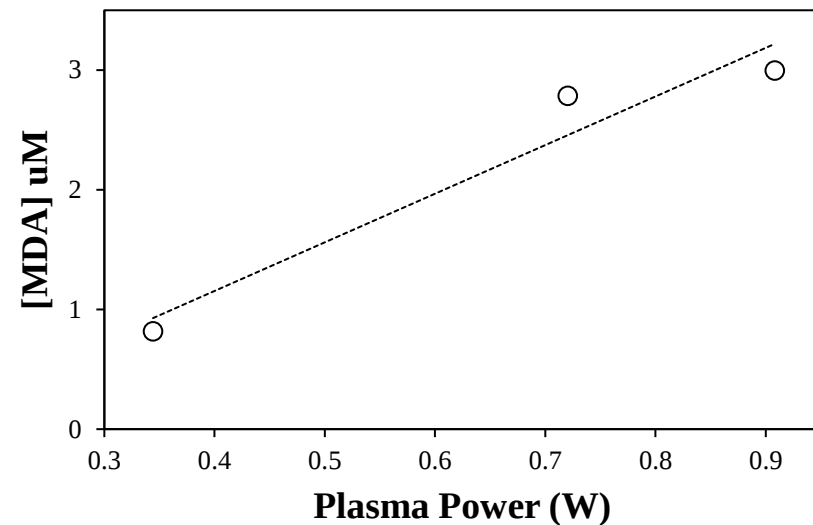
- Plasma-induced lipid peroxidation

- ⇒ Significant MDA level obtained for plasma CT
- ⇒ Equivalent MDA level obtained from H_2O_2 at $10^4 \times$ CT of droplet H_2O_2 .
- ⇒ **Evidence for direct OH interaction**

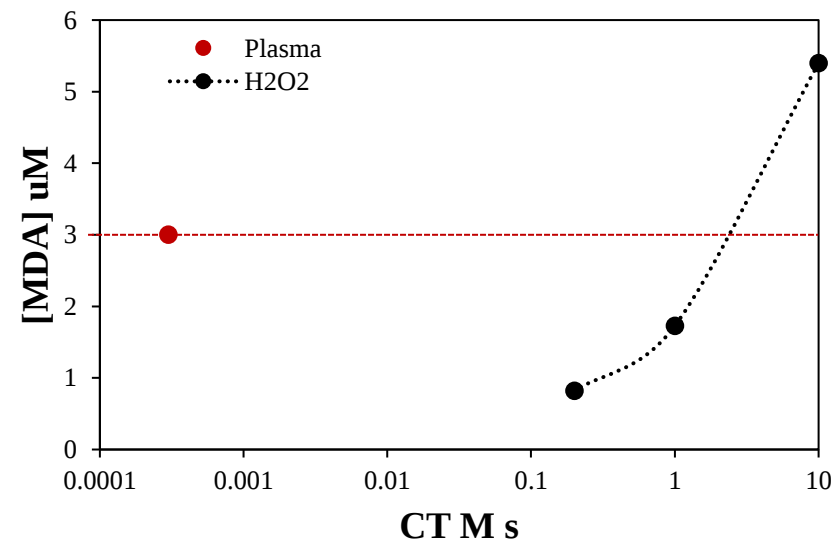
- Literature – plasma

- ⇒ Dolezalova, Alkawareek, Kim, Lee
- ⇒ MDA (μM levels) in minutes - hours

[MDA] vs Plasma Power



MDA v CT: Plasma, H_2O_2





Droplet in Plasma (DiP)



• Microscale droplets

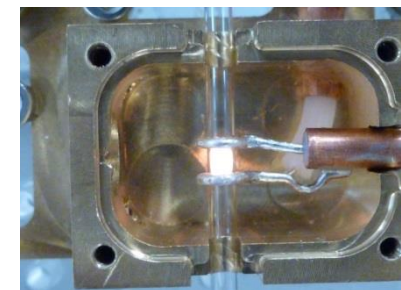
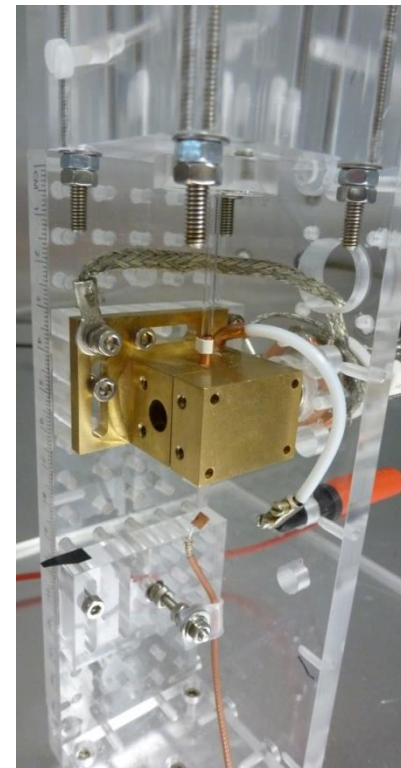
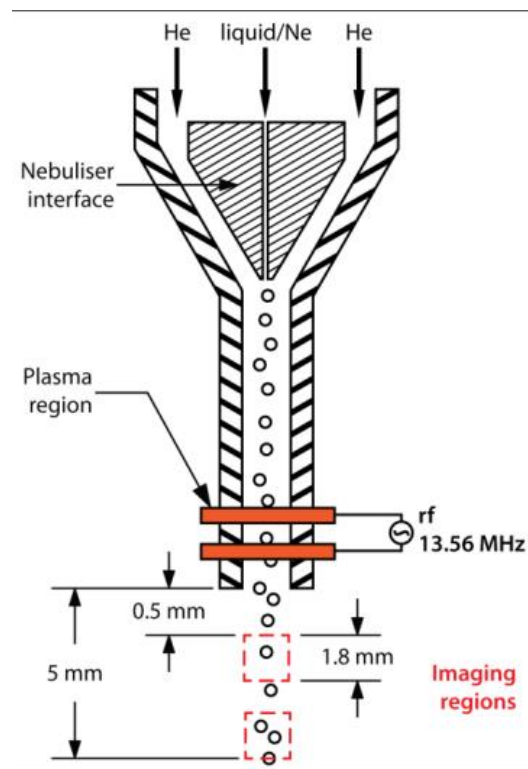
- ⇒ A stream of microdroplets transported through a low temperature RF plasma.
- ⇒ Low gas temperature, “large” size of droplet and short residence means evaporation is incomplete

• Non-thermal equilibrium plasma

- ⇒ Gas, ion temperature $\ll$ electron temperature
- ⇒ $T_{\text{gas}} \sim T_{\text{ion}} \ll T_{\text{e}}$.

• Plasma - Microdroplets

- ⇒ Stream of microdroplets flows through plasma
- ⇒ 50,000 droplets / sec
- ⇒ Exposed to plasma for **$\sim 120 \mu\text{s}$**
- ⇒ Droplet mean velocity **$\sim 10 \text{ ms}^{-1}$**

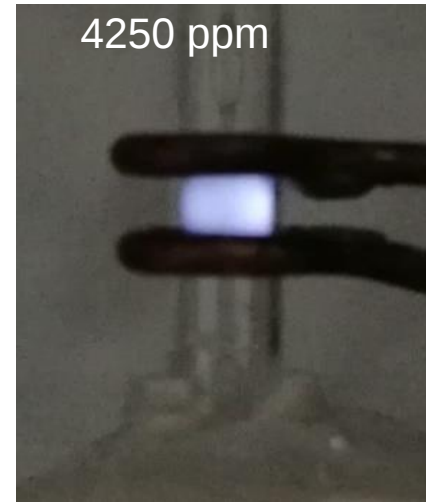
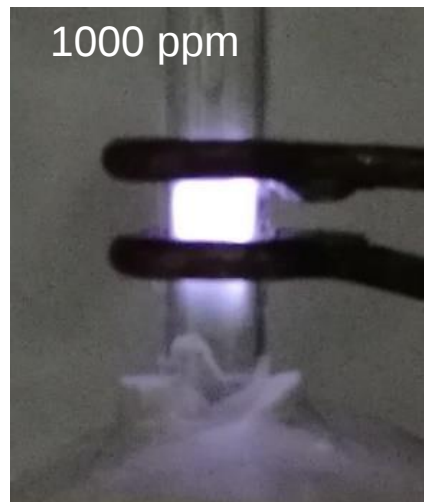
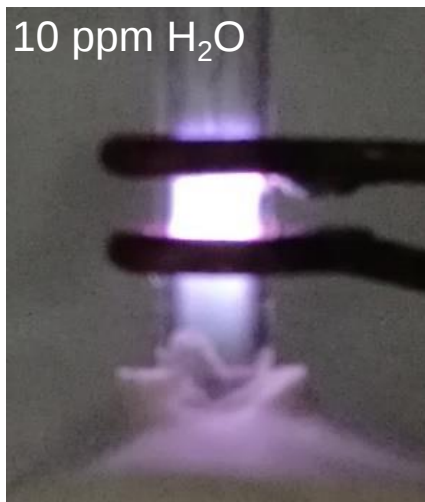


RF 13.56 MHz,
He: 3.5 slm,
Ne (aerosol): 1 slm
or Ar (aerosol): 1 slm

Maguire et al., Appl. Phys. Lett. 106, 224101 (2015);



- Without droplets
- Humidity
 - ⇒ Net input power decreases > 500ppm, as plasma becomes electronegative
 - ⇒ Power density (emission brightness) decreases at slower rate





- Without droplets

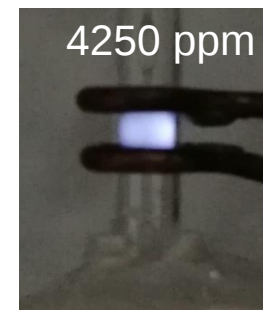
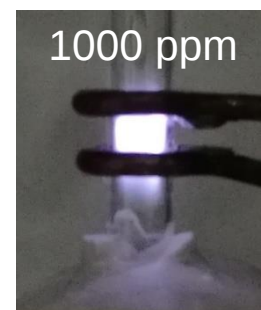
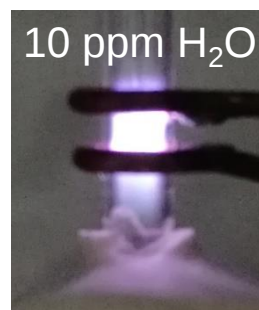
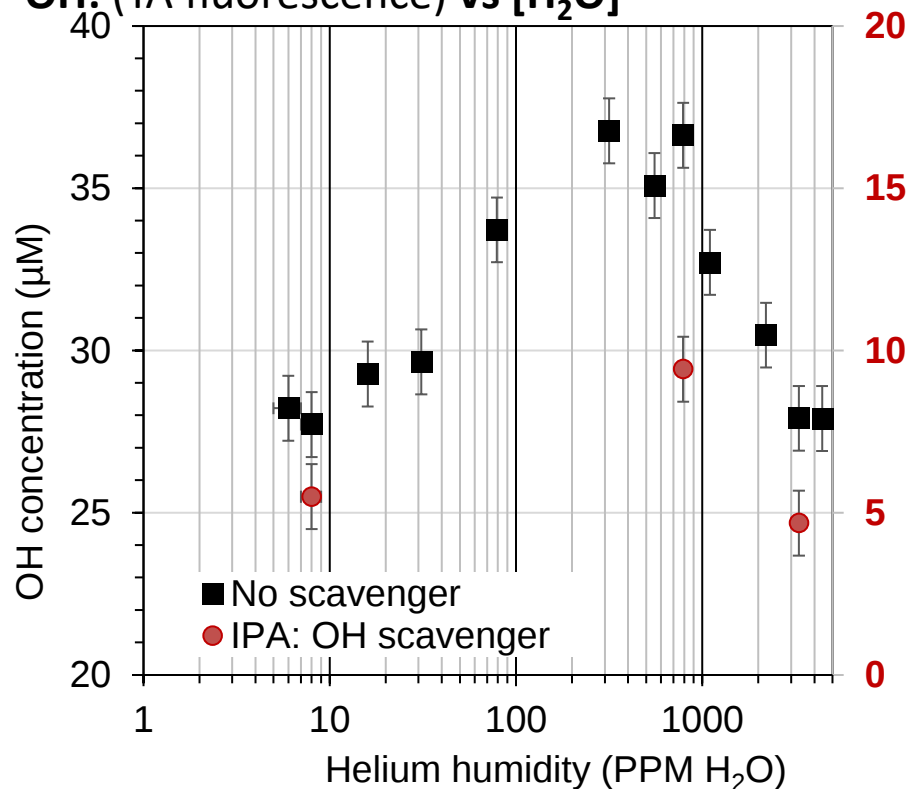
- Humidity

- Net input power decreases > 500ppm, as plasma becomes electronegative
- Power density (emission brightness) decreases at slower rate

- OH maximum

- Peaks ~500 ppm

OH: (TA fluorescence) vs [H₂O]





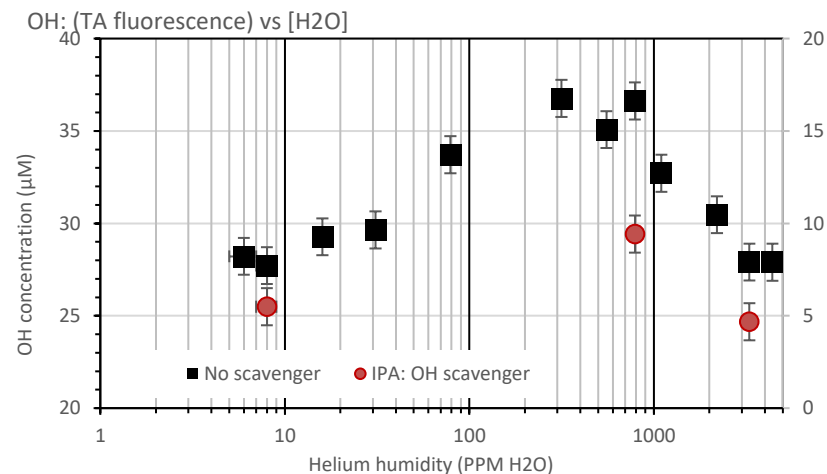
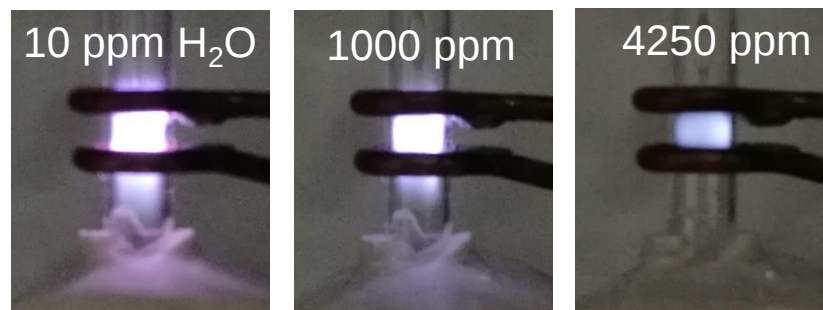
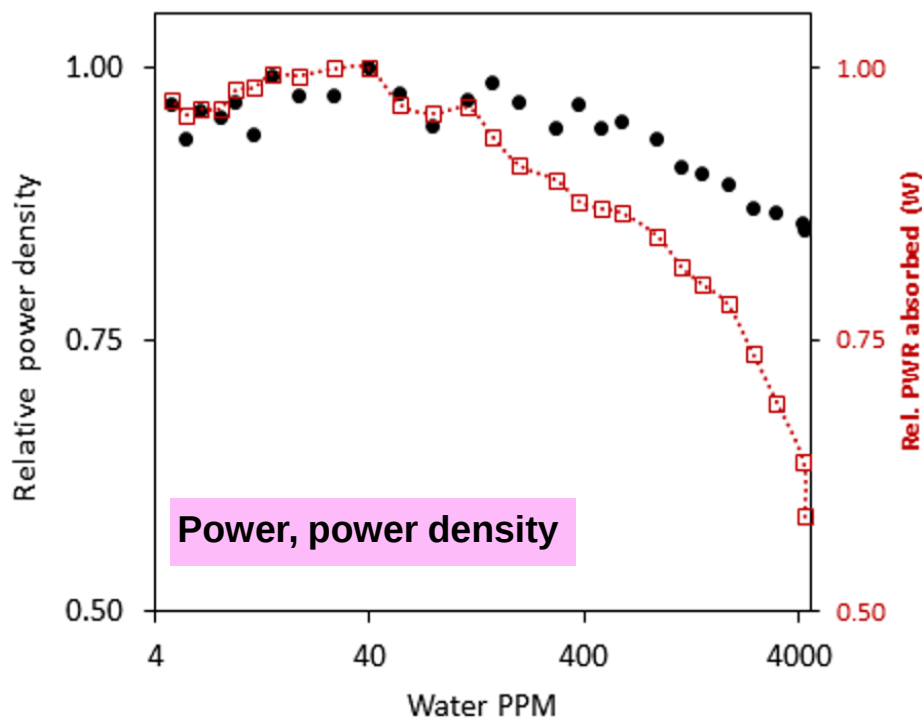
- Without droplets

- Humidity

- Net input power decreases > 500ppm, as plasma becomes electronegative
- Power density (emission brightness) decreases at slower rate

- OH maximum

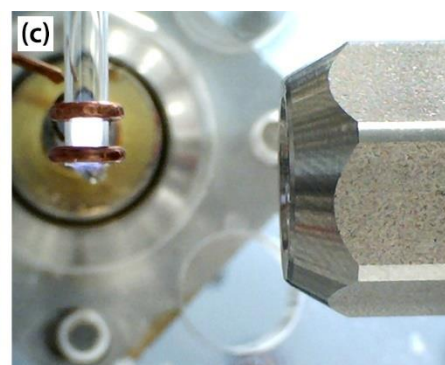
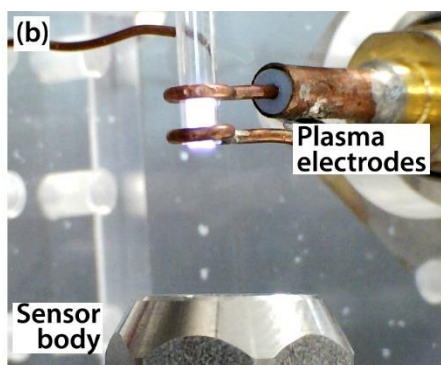
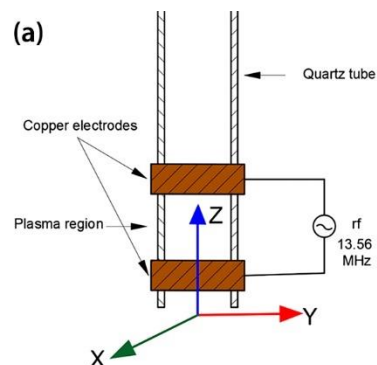
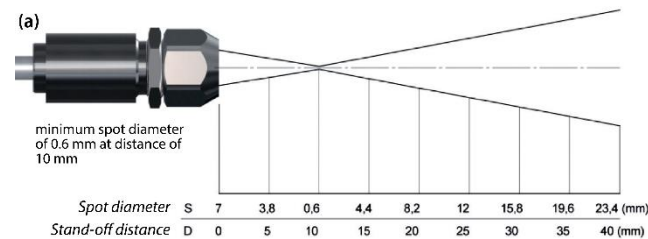
- Peaks ~500 ppm
- Reduction in power density > 500 ppm





IR temperature measurement

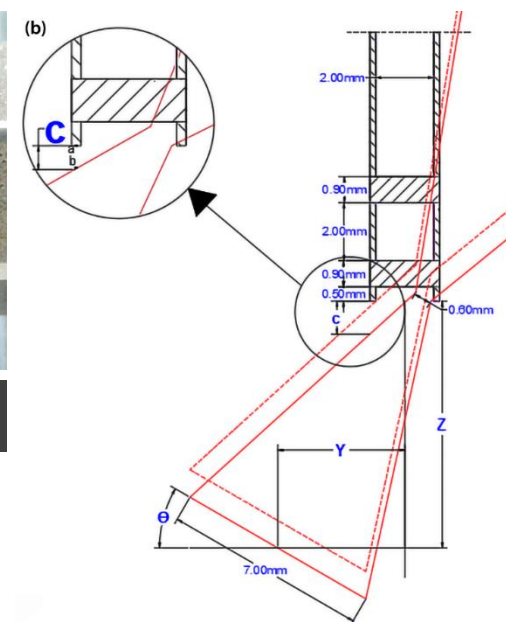
- Focal spot: minimum < 0.6 mm
- Calibrated – inner wall of plasma capillary tube
- Temperature readings – outer wall.



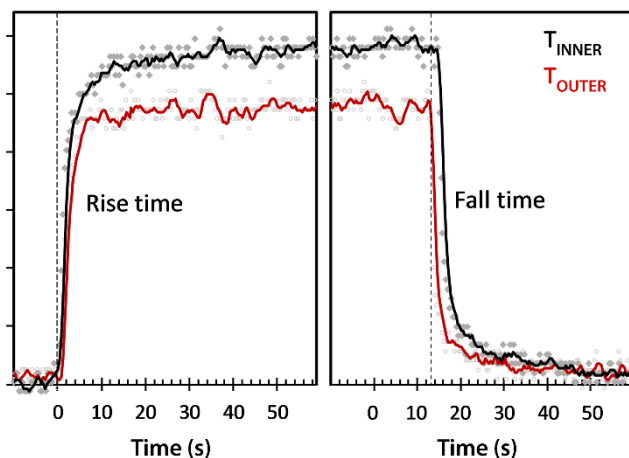
Plasma: electrodes and capillary

Calibration mode
Vertical – inner wall

Measurement mode
Horizontal – outer wall



Calibration mode
Vertical – inner wall



Temperature rise and fall times for inner wall (black) and outer wall (red). Dashed lines indicate the plasma ignition and extinction times obtained from photodiode response.

Continuous gas temperature measurement of cold plasma jets containing microdroplets, using a focussed spot IR sensor

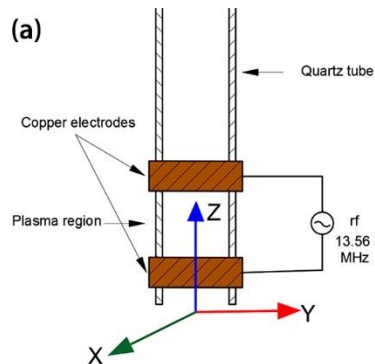
N Hendawy et al 2020 *Plasma Sources Sci. Technol.* **29** 085010

<https://doi.org/10.1088/1361-6595/aba2aa>

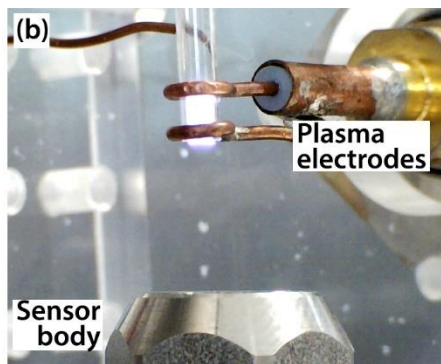


- Plasma only

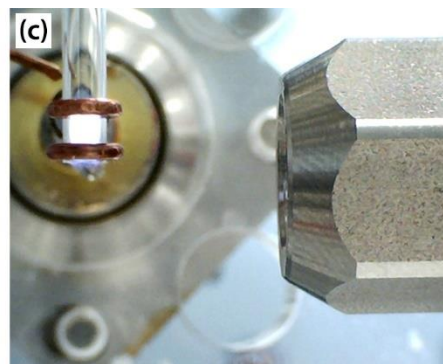
- ◉ Range: 28 °C to 45 °C
- ◉ Depends on power, flow



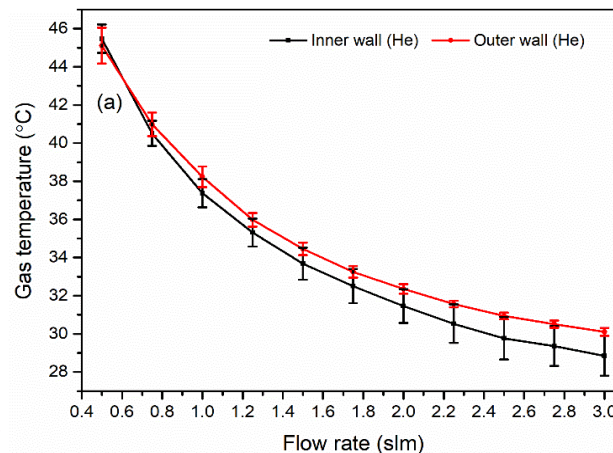
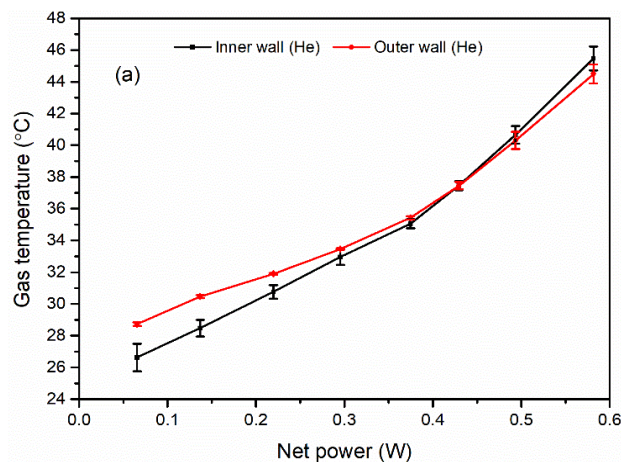
Plasma: electrodes and capillary



Calibration mode
Vertical – inner wall



Measurement mode
Horizontal – outer wall



Continuous gas temperature measurement of cold plasma jets containing microdroplets, using a focussed spot IR sensor

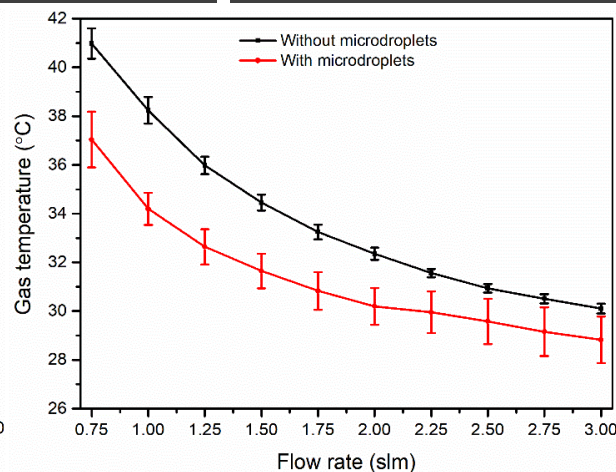
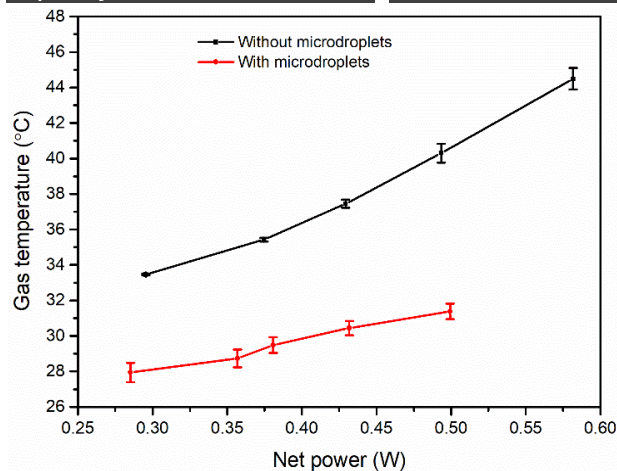
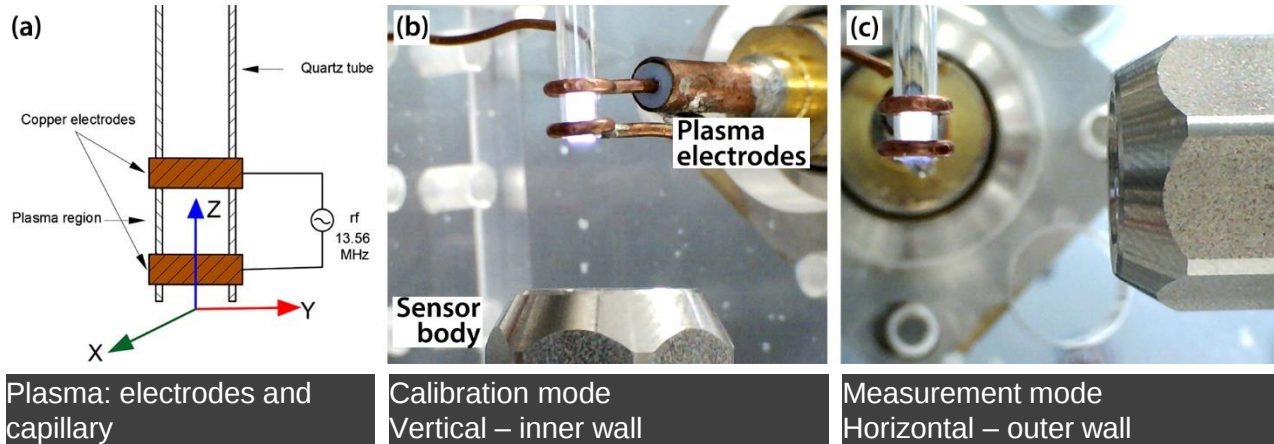
N Hendawy et al 2020 *Plasma Sources Sci. Technol.* **29** 085010

<https://doi.org/10.1088/1361-6595/aba2aa>



• Plasma with droplets

- Reduction in temperature, up to 12 °C.
- Depends on power, flow



Continuous gas temperature measurement of cold plasma jets containing microdroplets, using a focussed spot IR sensor

N Hendawy et al 2020 *Plasma Sources Sci. Technol.* **29** 085010

<https://doi.org/10.1088/1361-6595/aba2aa>



RF Plasma jets, different configurations

- Sremački 2021: ~300 K, no increase with droplets

⇒ Estimate, no measurement

Influence of aerosol injection on the liquid chemistry induced by an RF argon plasma jet

Ivana Sremački, Giuliana Bruno, Helena Jablonowski, Christophe Leys, Anton Yu Nikiforov and Kristian Wende, (2021) *Plasma Sources Sci. Technol.* *In press.* <https://doi.org/10.1088/1361-6595/abe176>

- Oinuma 2020: 320 K – 350 K

⇒ OH(A) emission

⇒ Measured: plasma only, no droplets

⇒ Temperature increases in direction of flow

Controlled plasma–droplet interactions: a quantitative study of OH transfer in plasma–liquid interaction

Gaku Oinuma, Gaurav Nayak, Yanjun Du and Peter J Bruggeman, 2020 *Plasma Sources Sci. Technol.* **29** 095002, <https://doi.org/10.1088/1361-6595/aba988>

- Nitta 2021: 1000 K – 1100 K

⇒ N₂ 2nd positive system

⇒ Measured: plasma with droplets

Plasma-assisted synthesis of size-controlled monodisperse submicron gold particles using inkjet droplets

Kaishu Nitta, Yoshiki Shimizu, Kazuo Terashima and Tsuyohito Ito, 2021 *J. Phys. D: Appl. Phys.* **54** 33LT01, <https://doi.org/10.1088/1361-6463/ac02f8>



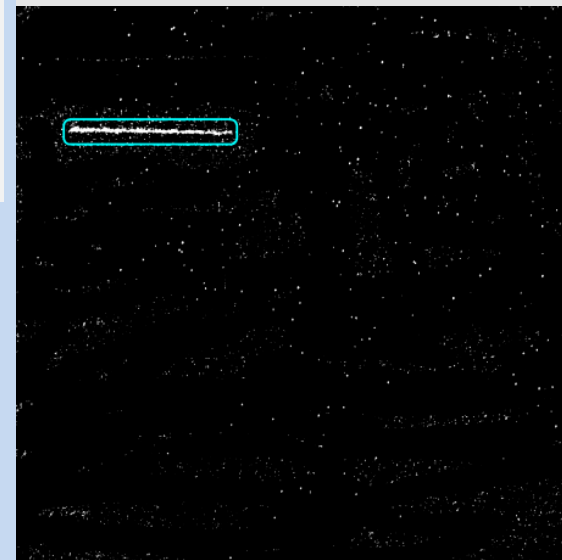
Basic plasma, droplet conditions



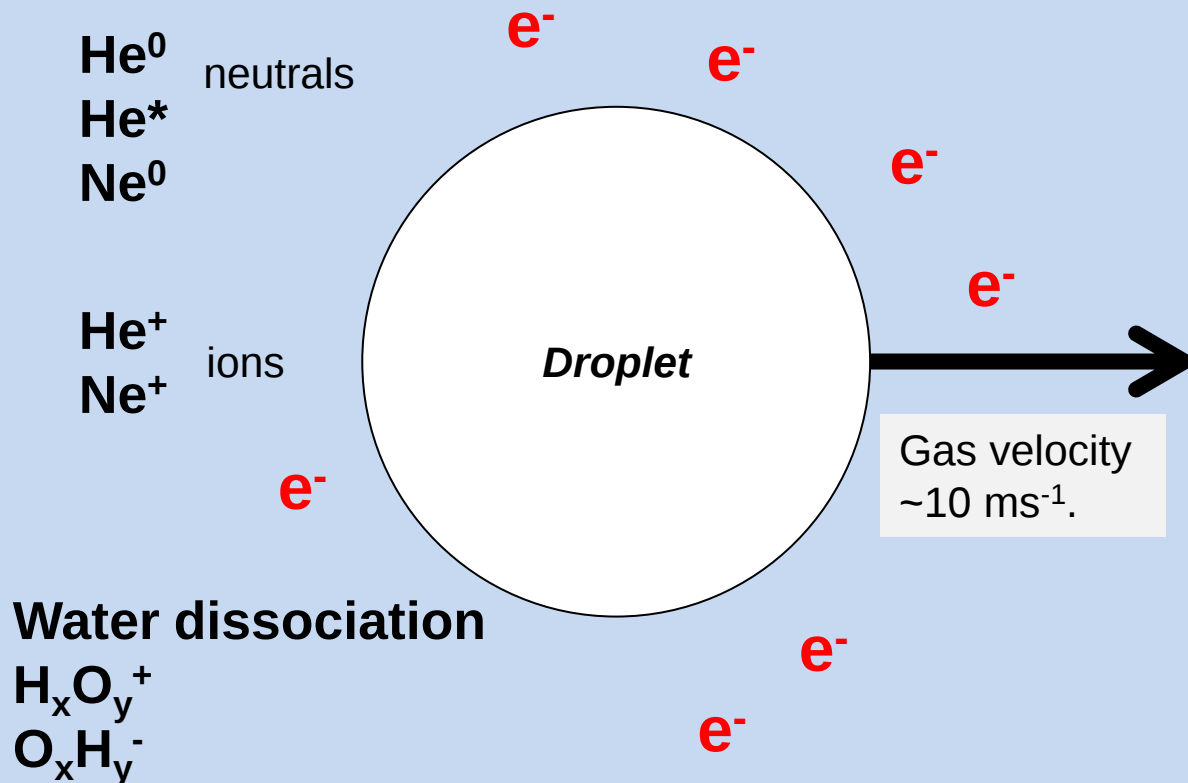
RF 13.56MHz
 n_e : $10^{12} - 10^{14} \text{ cm}^{-3}$.
Reactor diameter:
2mm

HeNe plasma (5:1)
Laminar axial flow
 $\sim 10^4$ droplets per second
Residence time in plasma: $\sim 100 \mu\text{s}$
Droplet diameter average: $15 \mu\text{m}$

High speed imaging



**~ 5 droplets in plasma
region at any instant**



Plasma region

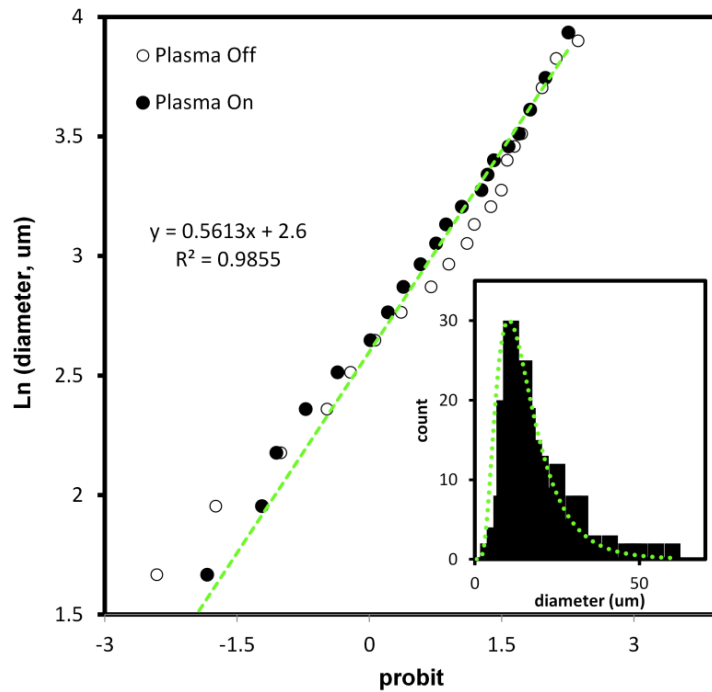


• Evaporation

- ⇒ H₂O production rate, delivered into plasma

• Droplet Size Distribution

- ⇒ Obtained from imaging in flight
- ⇒ 15 μm (CMD), no plasma

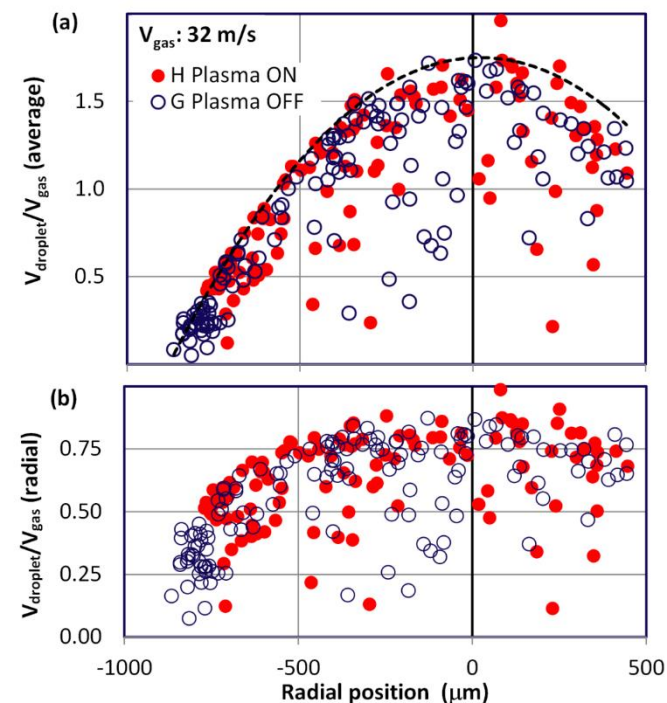


• Velocity Distribution

- ⇒ V(r) measured by imaging (but outside tube)
- ⇒ Drop travelling at 75% velocity of gas
- ⇒ Is this true inside tube?

• Stokes Flow regime

- ⇒ Determines whether convection or diffusion carries H₂O away from droplet into plasma





RF 13.56MHz
 $n_e: 10^{12} - 10^{14} \text{ cm}^{-3}$.

heating

He^0

He^*

Ne^0

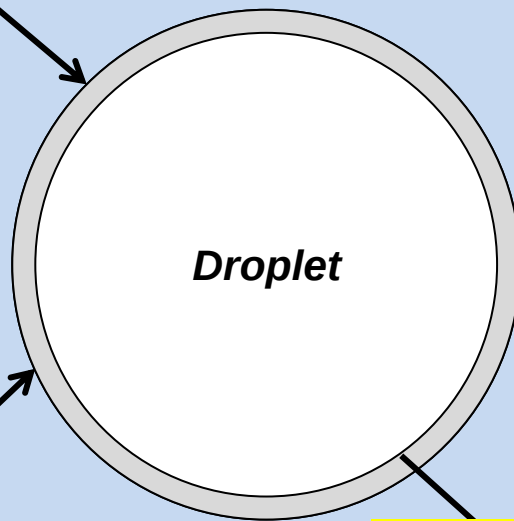
neutrals

He^+

Ne^+

ions

recombination
heating



Evaporation

Evaporation

Droplet size

$15\mu\text{m}$ (CMD) $\rightarrow$ $13\mu\text{m}$ (CMD)

Evaporation $\sim D^2$

Average Evaporation rate:

$5 \times 10^{-8} \text{ m}^2 \text{ s}^{-1}$.

Droplet loss by evaporation

Lost: smaller droplets $< 4\mu\text{m}$

$\sim 5\%$ of the total droplet number,

$\sim 0.05\%$ of the total liquid flow

Humidity

Average humidity increase due to evaporation $< 100\text{ppm}$

Plasma region



RF 13.56MHz
 $n_e: 10^{12} - 10^{14} \text{ cm}^{-3}$.

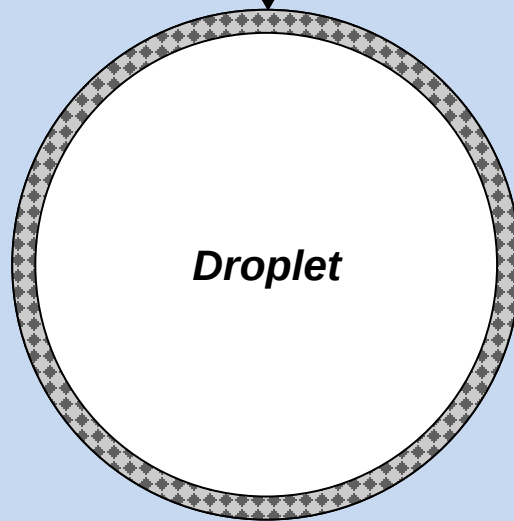
He^0
 He^* neutrals
 Ne^0

He^+
 Ne^+ ions

Water
dissociation
 H_xO_y^+
 O_xH_y^-

e^-

Droplet charging



Net electron flux initially
Droplet charges rapidly until it reaches
Negative floating potential
Then electron flux = ion flux
Timescale ns, (ω_i)

Plasma region



RF 13.56MHz

$n_e: 10^{12} - 10^{14} \text{ cm}^{-3}$.

He^0

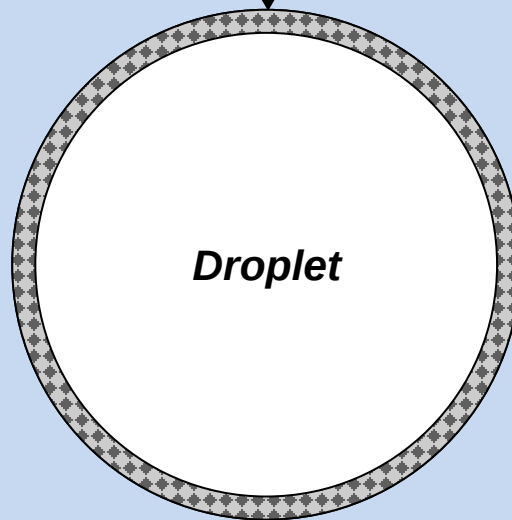
He^* neutrals

Ne^0

e^-

Droplet charging

He^+
 Ne^+ ions



Net electron flux initially
Droplet charges rapidly until it reaches
Negative floating potential
Then electron flux = ion flux
Timescale ns, (ω_i)

Plasma volume $\sim 10^{-8} \text{ m}^3$.
Total no. electrons: $> 10^{10}$.

Max. electrons lost to droplet 0.1%

Plasma region

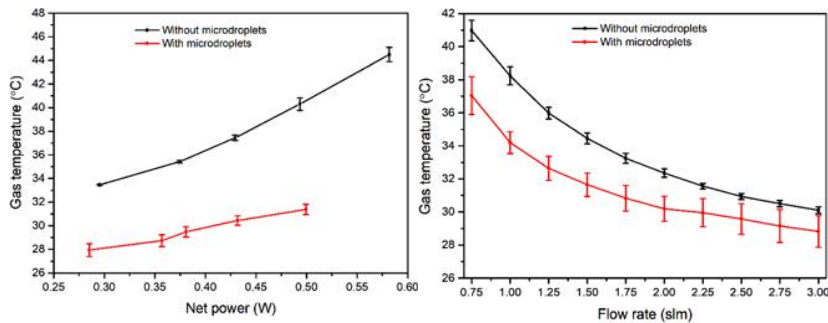


Electron flux to droplet



• Droplet addition

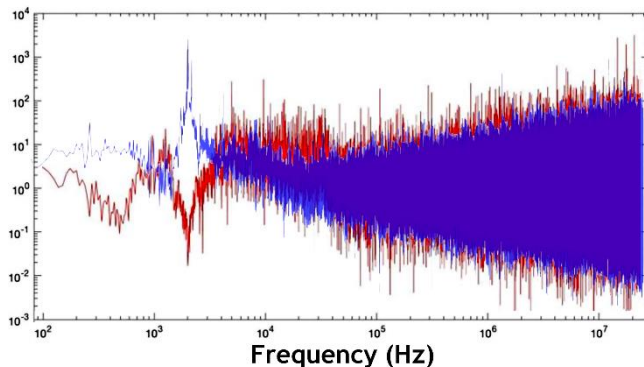
- Reduction in gas temperature
- Reduction in plasma volume



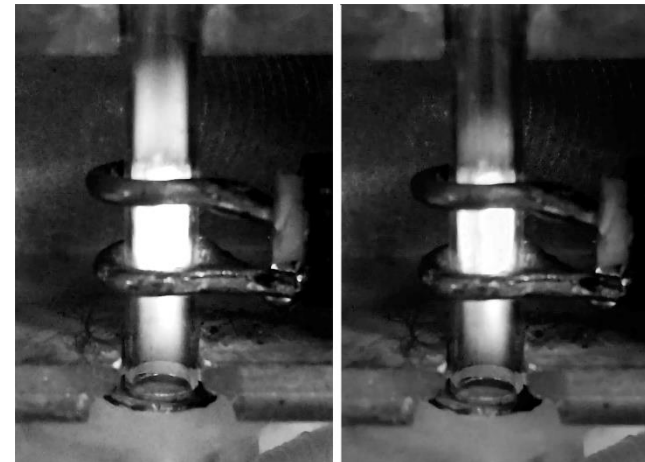
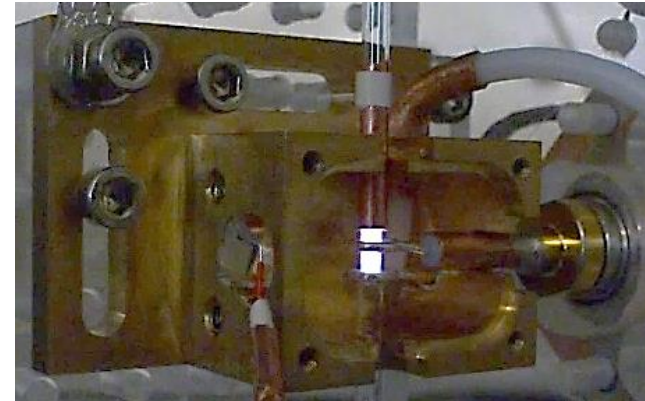
N Hendawy et al 2020 *Plasma Sources Sci. Technol.* **29** 085010

• Probe electrodes

- 0.1 mm diameter
- 3 mm diameter
- Located 3 mm – 40 mm from plasma



Power spectral density plots from plasma exposed electrode (blue), superimposed on that of plasma with droplets.



Plasma length between electrodes: 3.5 mm
 Distance GND electrode to probe electrode: 3mm
 Air gap end of capillary to probe electrode: 0.5 mm
 Left: Plasma only. Power (absorbed) 2.7 W
 Right: Plasma with droplets. Power (absorbed) 2.9 W

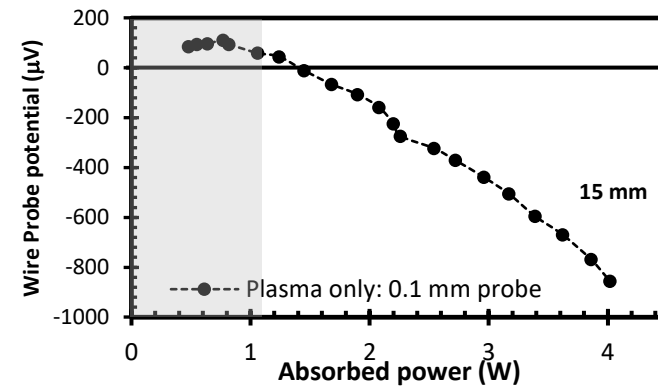


- Low power

- Distance 15 mm from plasma
- Probe: 0.1 mm
- Measured probe potential increases with power
- Probe is outside plasma afterglow region
- Plasma potential via resistor divider network
- Probe is not coupled to plasma

- High power

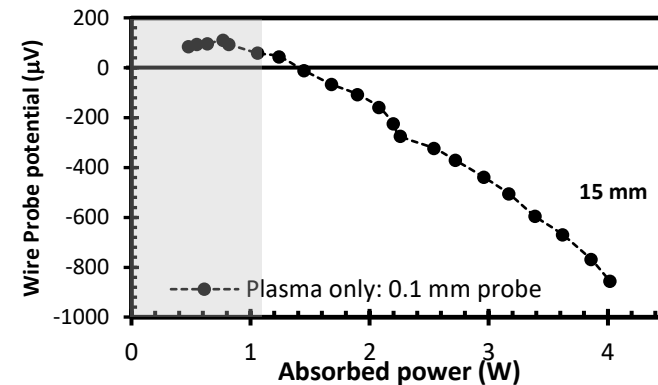
- Threshold (~1 W)
- Probe potential decreases with power
- High negative bias
- Probe is coupled to plasma





• Low power

- Distance 15 mm from plasma
- Probe: 0.1 mm
- Measured probe potential increases with power
- Probe is outside plasma afterglow region
- Plasma potential via resistor divider network
- Probe is not coupled to plasma

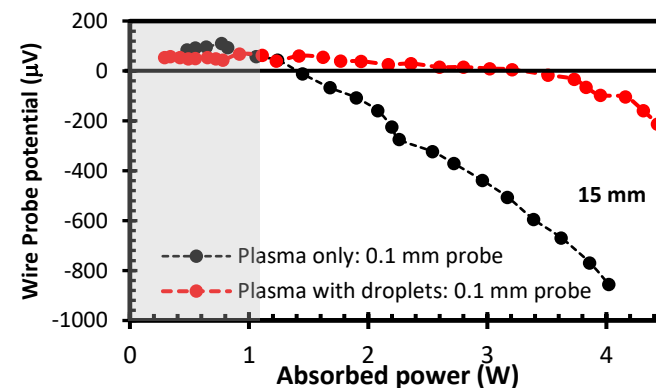


• High power

- Threshold (~ 1 W)
- Probe potential decreases with power
- High negative bias
- Probe is coupled to plasma

• With droplets

- Plasma volume is constricted
- Coupling threshold increases to 3.7 W
- Droplet impact on probe almost zero





- Large area Probe

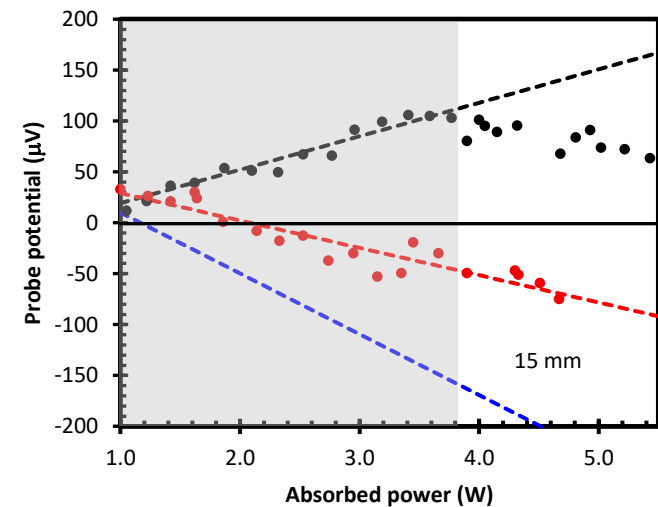
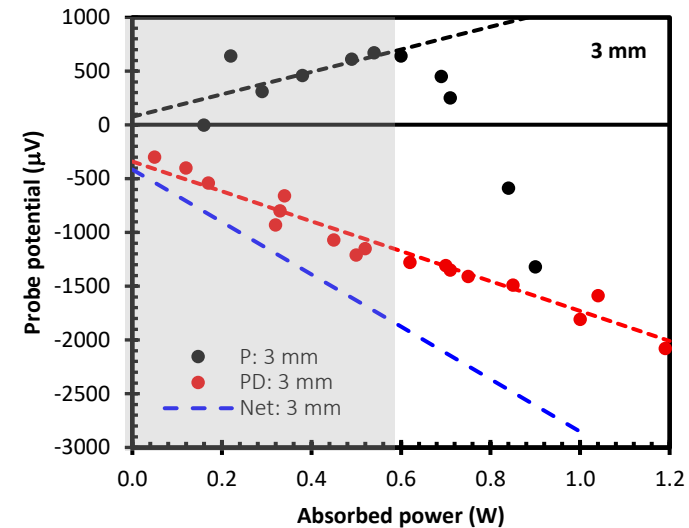
- Diameter: 3mm > plasma diameter (2mm)
- Droplet impact
- Below coupling threshold power

- Plasma only

- reference potential

- Plasma with droplets

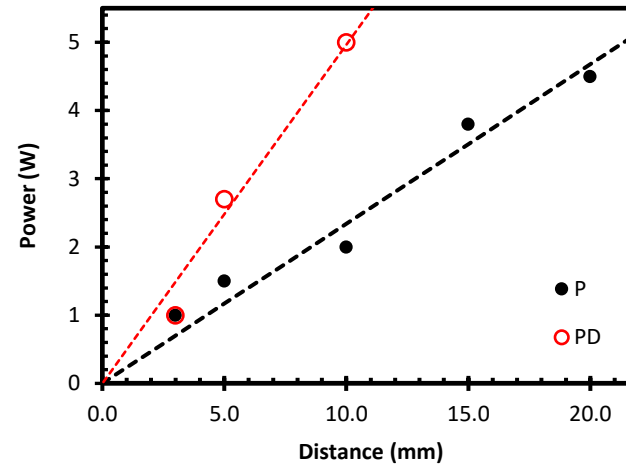
- reference potential and plasma potential induced due to negative droplet charge
- Average droplet charge: net potential difference and droplet rate
- Coupling threshold power increases with distance
- Charge increases with power, decreases with distance





- Plasma – Droplets

- ⇒ Plasma volume constriction
- ⇒ Large gap to probe
- ⇒ Higher power required to couple



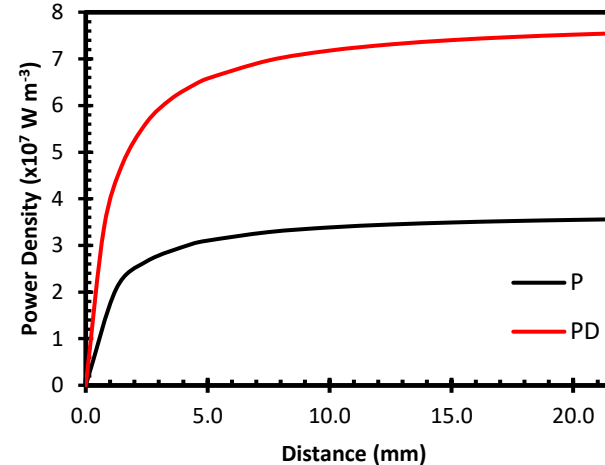
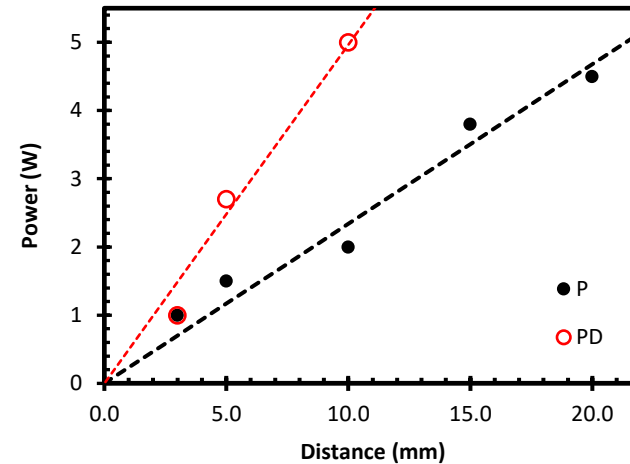


• Plasma – Droplets

- Plasma volume constriction
- Large gap to probe
- Higher power required to couple

• Power density

- Above 5mm distance, required power density is almost constant
- Power density for droplets x 3 for plasma only
- Note: 1 – 5 droplets in plasma simultaneously





- Large area Probe

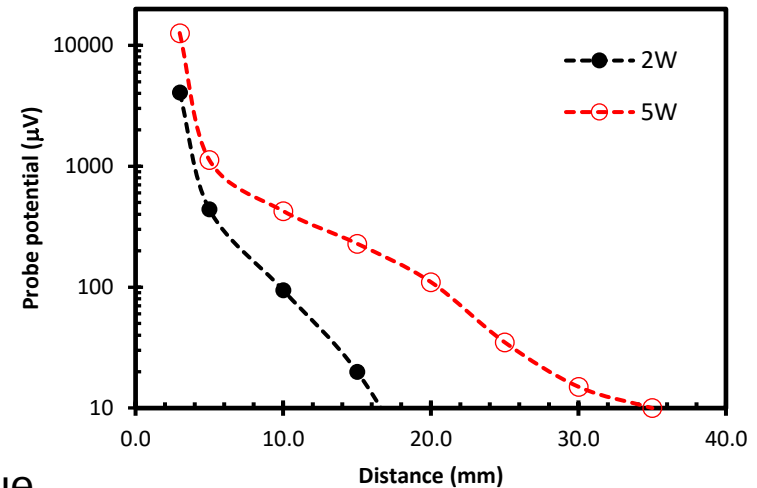
- Diameter: 3mm > plasma diameter (2mm)
- Droplet impact
- Below coupling threshold power

- Plasma only

- reference potential

- Plasma with droplets

- reference potential and plasma potential induced due to negative droplet charge
- Average droplet charge: net potential difference and droplet rate
- Coupling threshold power increases with distance
- **Charge increases with power, decreases with distance**





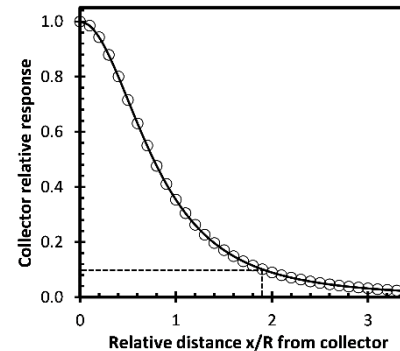
$$i = \frac{dq'}{dt} = \frac{qvR^2}{\sqrt{(R^2 + x^2)^3}}$$

• Image charge estimate

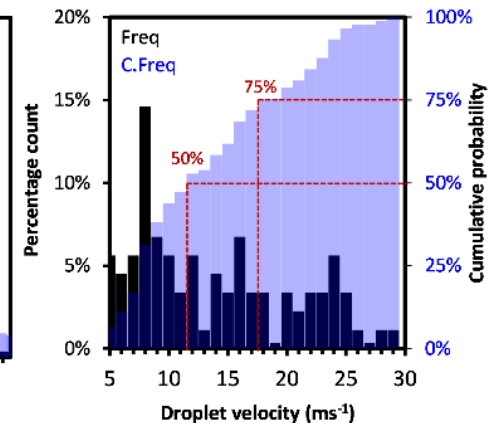
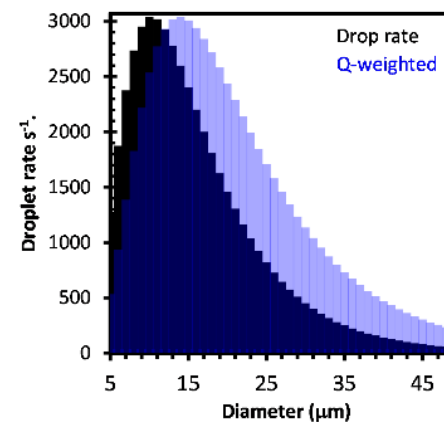
- Single charge
- x: moving droplet distance from probe
- v: droplet velocity

• Droplet stream

- Measured characteristics
- Droplet rate (all sizes) : 5×10^4
- v: average velocity
- R: electrode radius
- multiple droplets in probe capture zone

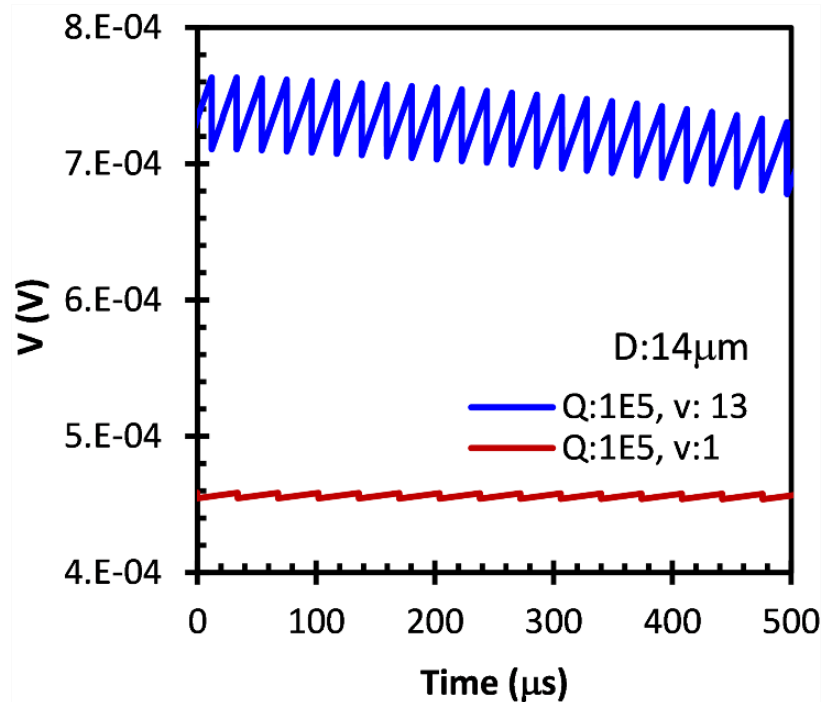


Electrode relative response to charged particle flux versus particle distance, normalised to electrode radius, R.



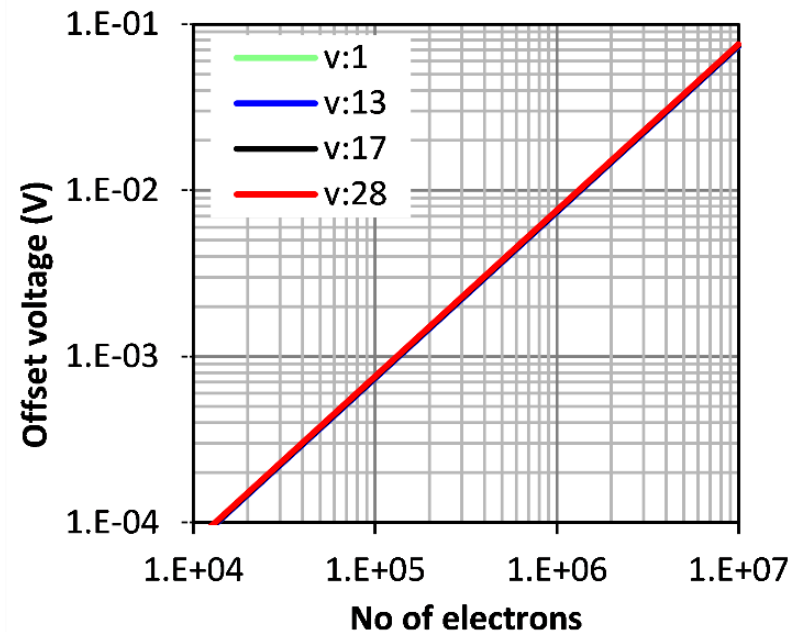
(a) Droplet rate versus size (count median diameter: **13.6 μm**, geometric std. deviation: 1.7) for a total droplet rate of 5×10^4 s⁻¹. Also shown: equivalent charge contribution, assuming a linear charge – diameter relationship. **60% droplets < 20 μm**

(b) Droplet velocity distribution and cumulative frequency distribution **showing 50% of droplets travel at ≤ 12 ms⁻¹, and 75% at ≤ 17 ms⁻¹**. The peak and average gas velocities within the capillary are ≤ 16 ms⁻¹ and ≤ 32 ms⁻¹ respectively, assuming laminar flow.



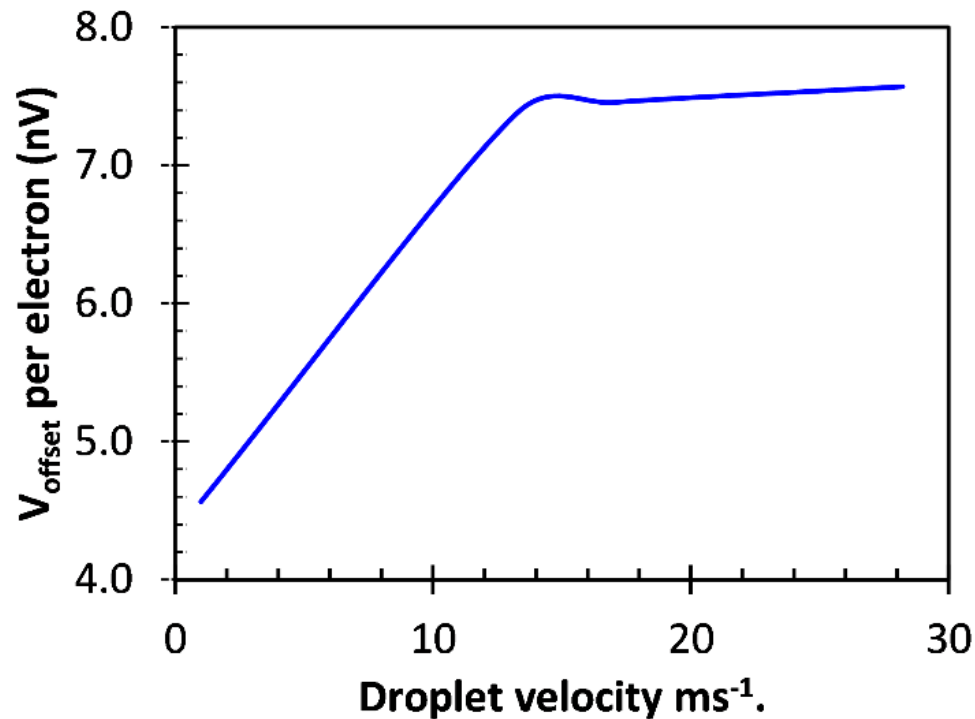
(a) Simulated waveforms for fixed droplet diameter ($14\mu\text{m}$) and charge (10^5 electrons) for different velocities

Probe bias plus ripple due to individual droplets



(b) offset voltage versus charge, for different droplet velocities.

Probe bias insensitive to velocity



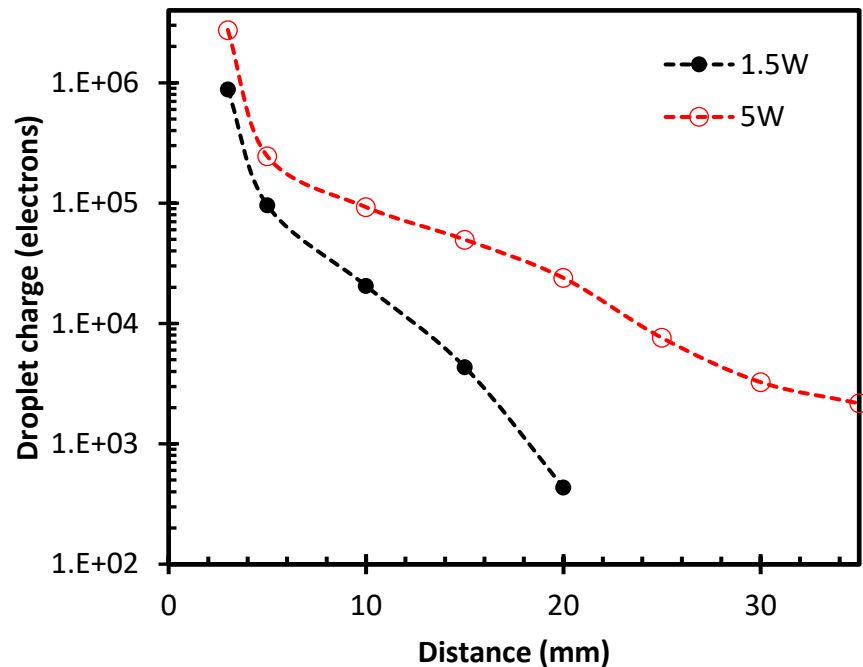
Calculated offset voltage per electron versus velocity.

- The simulation range extended a distance $4 \times R$ from an electrode of radius R .
- The droplet diameter (D) and spacing (G) was $14 \mu\text{m}$ and $v \times T_{\text{int}}$ respectively, where T_{int} is the droplet generation interval, $20 \mu\text{s}$.
- The minimum no of droplets was $4R/(D+G)$.



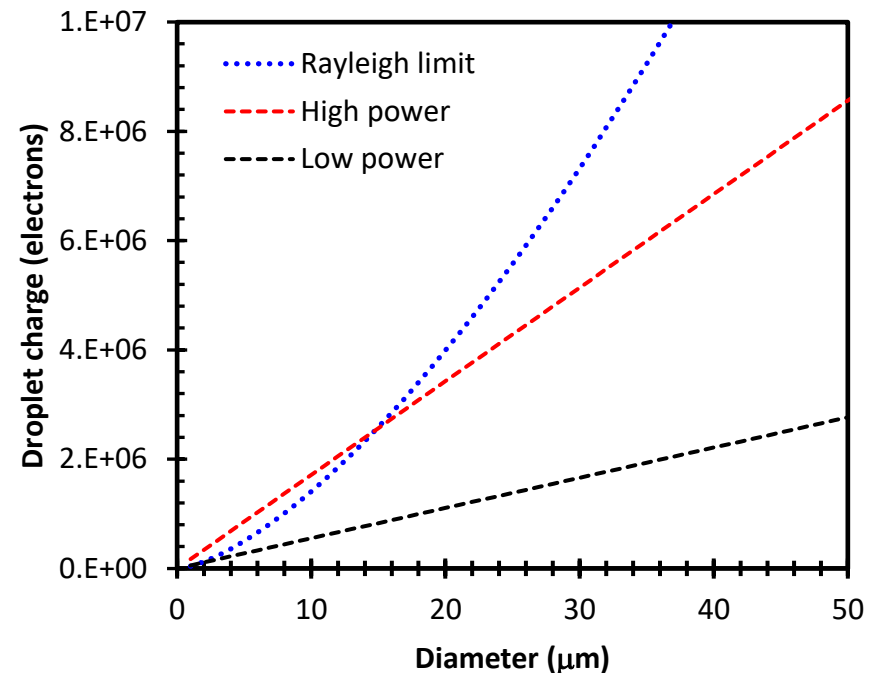
- Within plasma region

- $> 10^6$ electrons (1.5 W)
- $> 4 \times 10^6$ electrons (5 W)



- Rayleigh limit

- High power
- Diameters $\leq 15 \mu\text{m}$
- ~60% of droplet count





Droplet charge model



Collisional (high pressure) charge flux theory

No analytical solution

Standard orbital motion limited (OML) theory

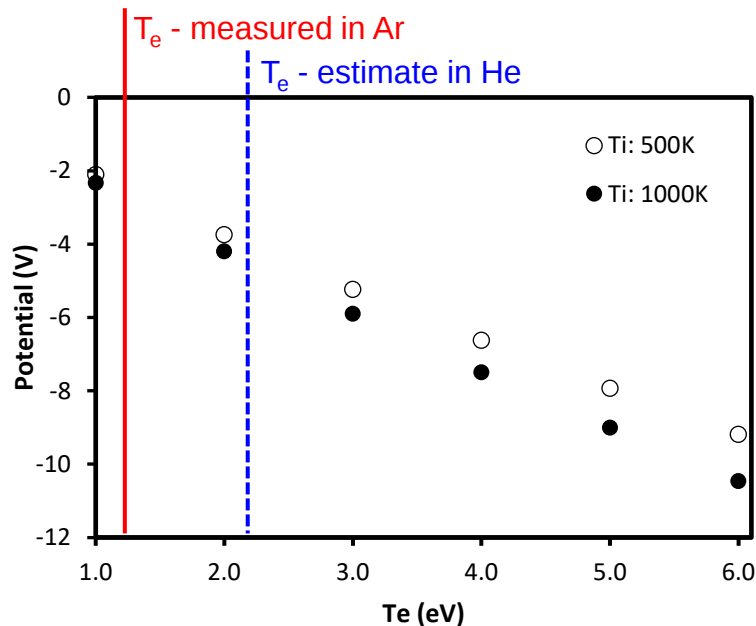
Collisionless, low pressure approximation - underestimate

Droplet potential obtained by equating ion and electron currents to and from the droplet i.e.

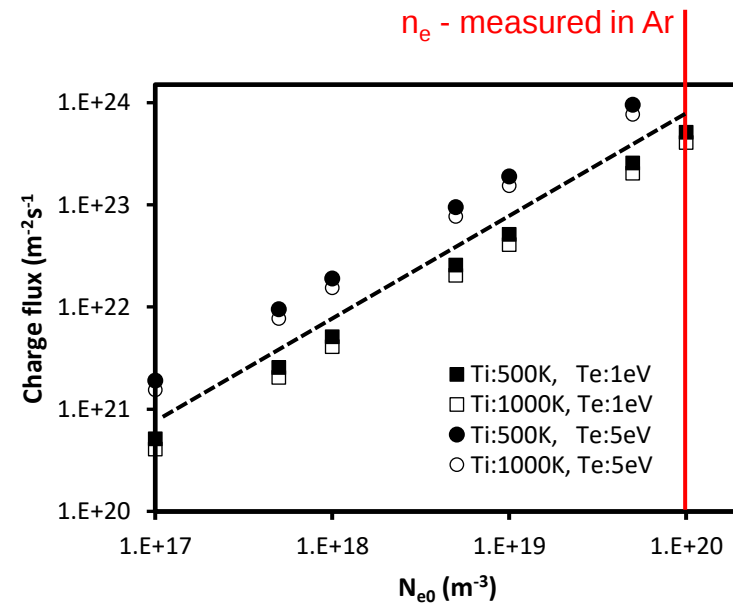
$$\left(\frac{T_e}{m_e}\right)^{1/2} \left[1 - \exp\left(-\frac{e|\varphi_s|}{K_B T_e}\right)\right] = \left(\frac{T_i}{m_i}\right)^{1/2} \left(\frac{e|\varphi_s|}{K_B T_i}\right)$$

total flux Γ is given by

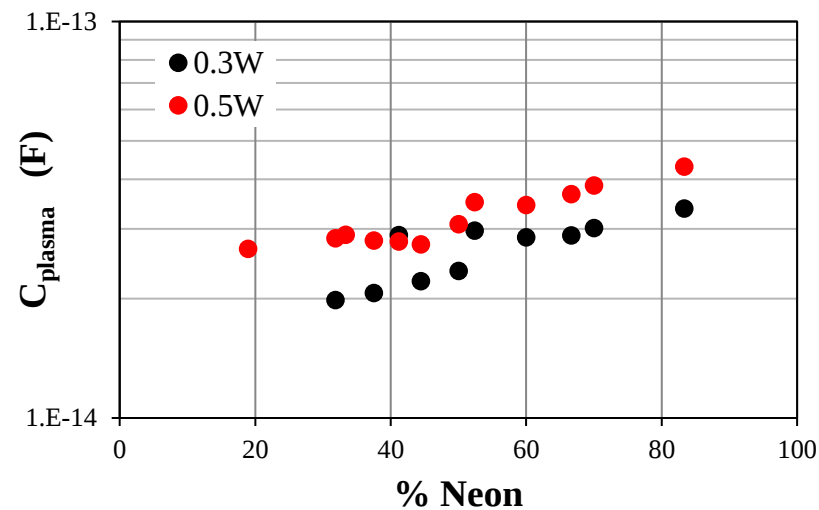
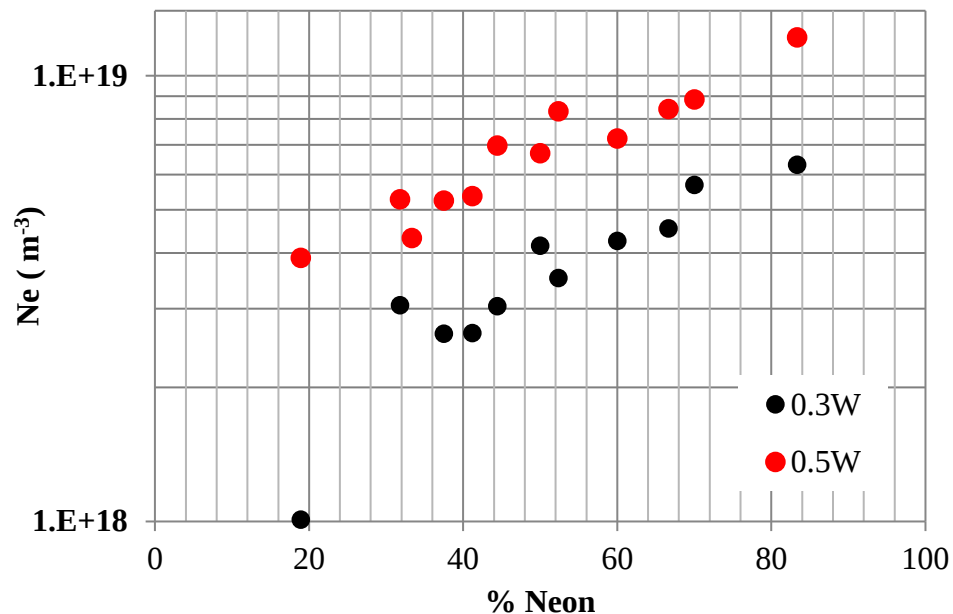
$$4\pi r_o^2 Z_i e n_{oi} \left(\frac{K_B T_i}{2\pi m_i}\right)^{1/2} \frac{e|\varphi_s|}{K_B T_i}$$



Droplet potential versus electron temperature, for two values of $T_i = 500K$, and $1000K$ calculated using Orbital Motion Limited (OML) theory.



Ion/electron OML flux to $15 \mu m$ droplet versus plasma density (n_{e0}) for $T_i = 500K$, and $1000K$ and upper/lower values of T_e of $1 eV$ and $5 eV$



Collisional mobility – impedance model

Impedance, phase measurements

- He 60%, 40% Ne, 0.3W

Time Averaged Sheath Width

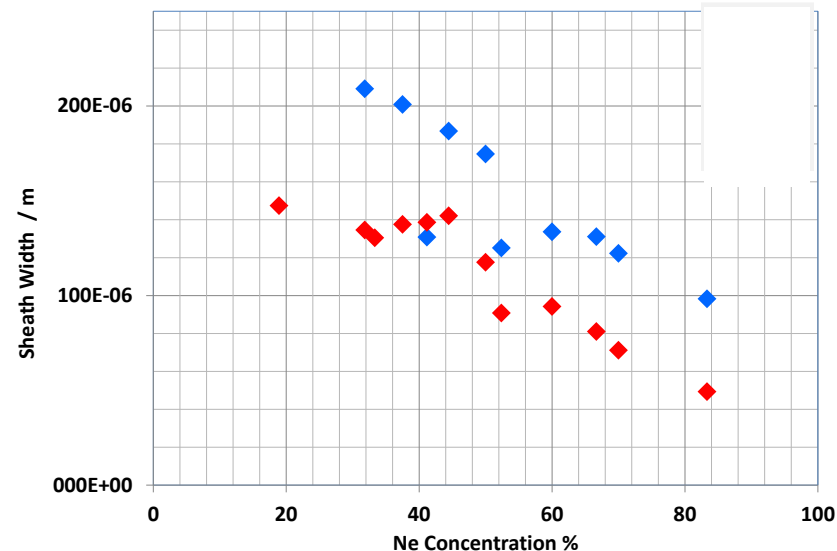
Gas $\sim 105 \mu m$

Gas & droplets $\sim 200 \mu m$

Time Averaged Electron Density

Gas $\sim 3 \times 10^{18} m^{-3}$

Gas & droplets $\sim 7 \times 10^{18} m^{-3}$





Collisional (high pressure) charge flux theory

No analytical solution

Standard orbital motion limited (OML) theory

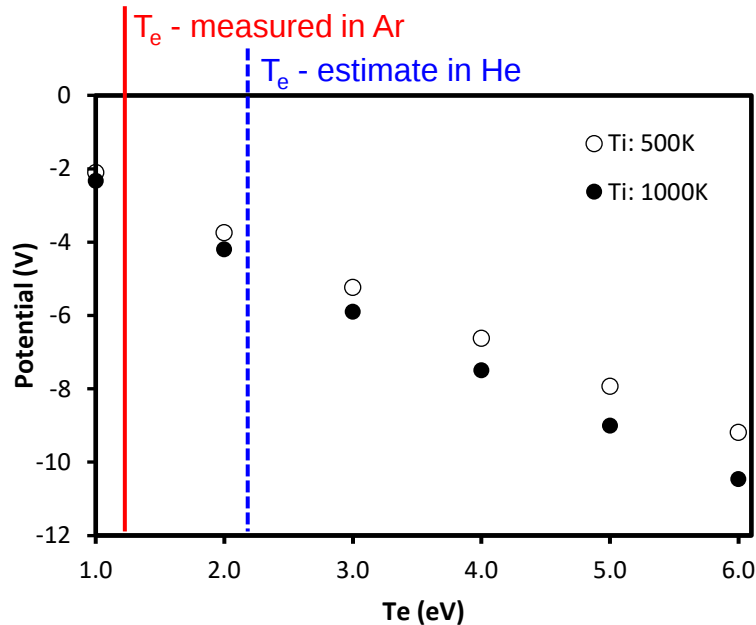
Collisionless, low pressure approximation - underestimate

Droplet potential obtained by equating ion and electron currents to and from the droplet i.e.

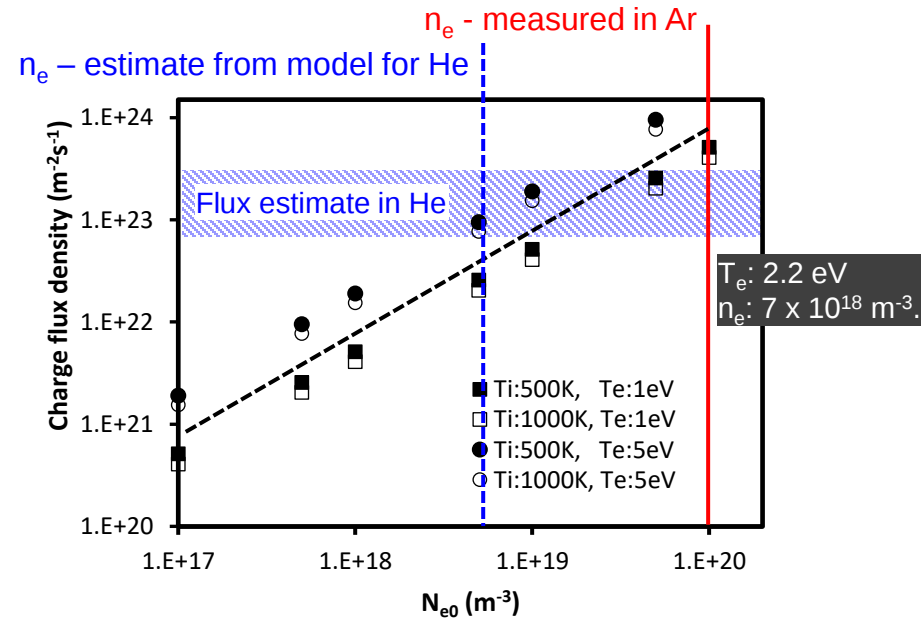
$$\left(\frac{T_e}{m_e}\right)^{1/2} \left[1 - \exp\left(-\frac{e|\varphi_s|}{K_B T_e}\right)\right] = \left(\frac{T_i}{m_i}\right)^{1/2} \left(\frac{e|\varphi_s|}{K_B T_i}\right)$$

total flux Γ is given by

$$4\pi r_o^2 Z_i e n_{oi} \left(\frac{K_B T_i}{2\pi m_i}\right)^{1/2} \frac{e|\varphi_s|}{K_B T_i}$$



Droplet potential versus electron temperature, for two values of $T_i = 500K$, and $1000K$ calculated using Orbital Motion Limited (OML) theory.



Ion/electron OML flux to $15 \mu m$ droplet versus plasma density (n_{e0}) for $T_i = 500K$, and $1000K$ and upper/lower values of T_e of $1 eV$ and $5 eV$



Solvated electrons

Flux and charge in a fully collisional plasma



- Solvated electrons

- ⇒ Electron flux to liquid, electron solvation
- ⇒ Bulk liquid
- ⇒ Penetration depth ~ 12 nm
- ⇒ Surface concentration ~ 1 mM

The solvation of electrons by an atmospheric-pressure plasma

Paul Rumbach, David M. Bartels, R. Mohan Sankaran & David B. Go, *Nat Commun* **6**, 7248 (2015). <https://doi.org/10.1038/ncomms8248>

- Collisional theory

- ⇒ regimes depend on Debye length, sheath width, mean free path, probe diameter
- ⇒ approximate analytical solutions available for nanoparticles but not for microparticles

Continuum Theory of Spherical Electrostatic Probes

C. H. Su and S. H. Lam, *Phys. Fluids* **6**, 1479 (1963), <http://dx.doi.org/10.1063/1.1710971>

- PIC simulation

- ⇒ All physically allowed free parameters
- ⇒ electron Debye - body radius ratio, ion - electron temperature ratio, and
- ⇒ analytically in rigorously defined asymptotic regimes (weak & strong bias, weak & strong shielding, thin and thick sheath).

Continuum-plasma solution surrounding non-emitting spherical bodies

L. Patacchini and I. H. Hutchinson, *Phys. Plasmas* **16**, 062101 (2009)
<https://doi.org/10.1063/1.3143038>

- Scale lengths

- Reactor

- ⇒ 10^{-3}

- Droplet

- ⇒ 10^{-5}

- Sheath around droplet?

- Debye length?

- Mean free path

- ⇒ 10^{-7}

- Solvated electron layer

- ⇒ 10^{-8} to 10^{-9}



High Pressure model (Collisional)

- In high pressure plasmas, ion and electron collisions with neutrals modify the charge flux to the surface.
- Analytic expression for charge flux to a probe is not available.

Model implementations

1. COMSOL fluid model. 1D radial
2. 1D radial analytical / numerical model for both $\lambda_{i,e}$ and $\lambda_{Di,e} \ll D$, the droplet diameter, based on mobility/diffusion assumptions

– e.g. see Patacchini and Hutchinson. "Continuum plasma solution surrounding non-emitting spherical bodies." Physics of Plasmas 16.6 (2009): 062101-16

Model regimes

Weak collisionality:

Ion mean free path $\lambda_i < \text{Debye length } \lambda_{Di}$,

Strong collisionality:

Electron mean free path $\lambda_e \ll \lambda_{De}$.

Particle scaling factors

$R/\lambda_i : R/\lambda_{Di} : R/\lambda_e : R/\lambda_{De}$.

Ion, electron temperatures

Inferred from measurements in Ar

Electron, ion density

From collisional – impedance model

$$\nabla \left(-\frac{\partial n_i}{\partial r} - \frac{1}{\tau} n_i \frac{\partial \phi}{\partial r} \right) = 0$$

$$\nabla \left(-\frac{\partial n_e}{\partial r} + n_e \frac{\partial \phi}{\partial r} \right) = 0$$

$$\nabla \left(\frac{\partial \phi}{\partial r} \right) - \frac{1}{\lambda_{De}^2} (n_e - n_i) = 0$$

$$\nabla(x) = 1/r^2 \partial / \partial r (r^2 x)$$

$$\Gamma_i^p = \frac{N_\infty D_i}{R_p} \frac{\partial n_i}{\partial r} (r_p)$$

$$\Gamma_e^p = (N_\infty D_e / R_p) \partial n_e / \partial r (r_p)$$



- Plasma – droplet collisional model

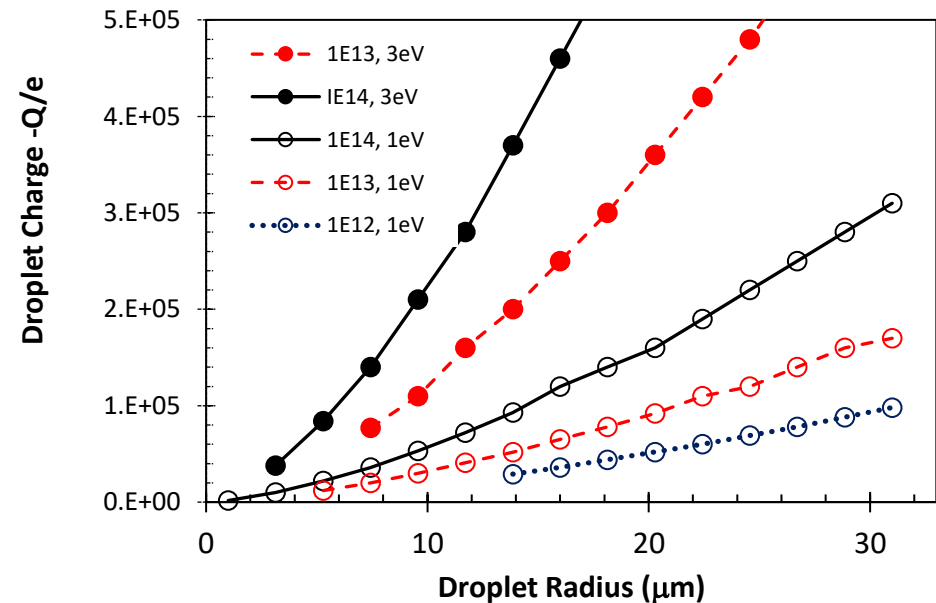
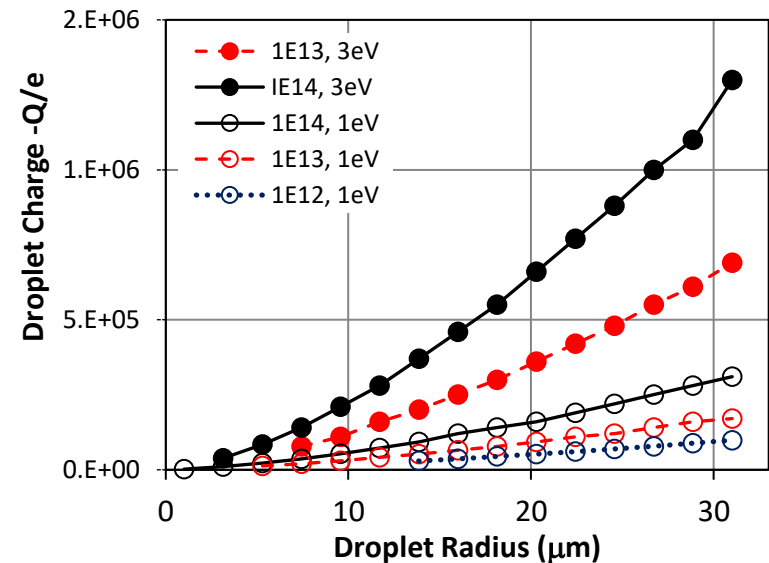
$$\lambda_e \ll \lambda_{De}, \quad \lambda_{De} \ll r_{NP}$$

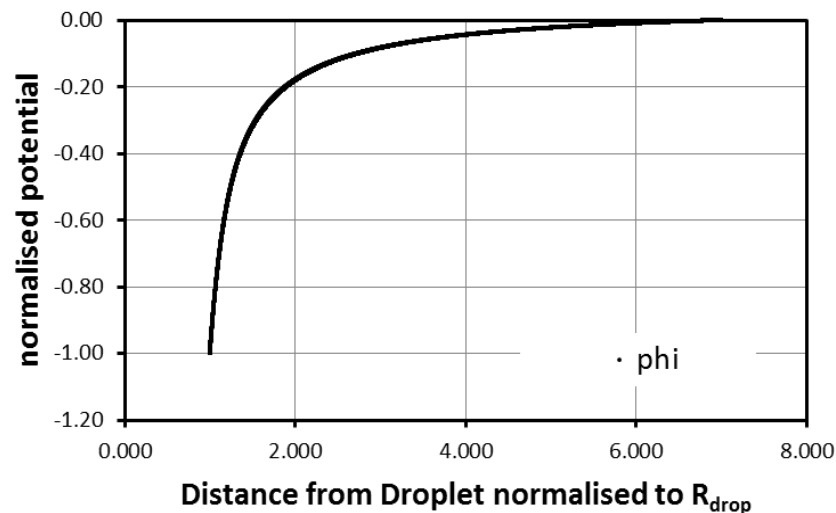
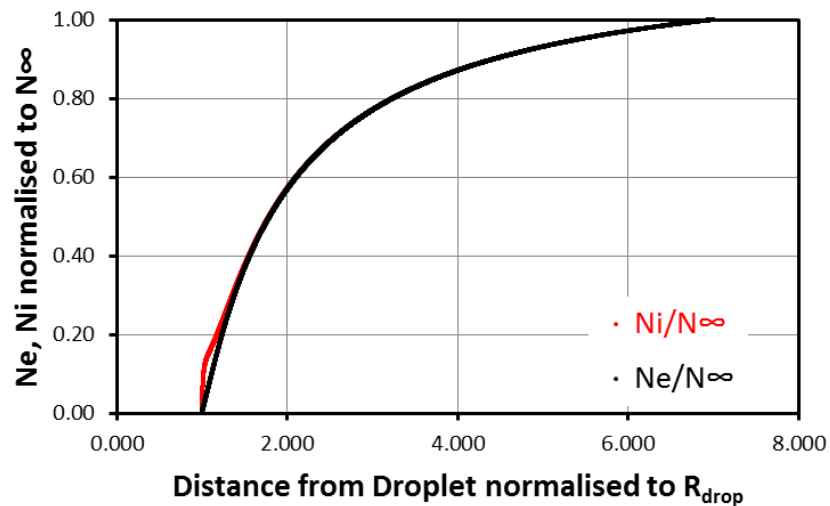
- Highly collisional

- Hydrodynamic solution
- Simulations
- Asymptotic analytical approximations

Model Output

- $Q_{\text{drop}} \propto R_{\text{drop}}$
 - $n_e: 1 \times 10^{12} - 1 \times 10^{14} \text{ cm}^{-3}$.
 - Average R: $Q_d = \sim 10^5 e$
 - $R = 13 \text{ } \mu\text{m}$: $Q_d = 5 \times 10^4 e - 2 \times 10^5 e$
 - Electron flux**
 - $10^{20} - 5 \times 10^{23} \text{ m}^{-2} \text{ s}^{-1}$
 - Measured charge significantly higher than model**





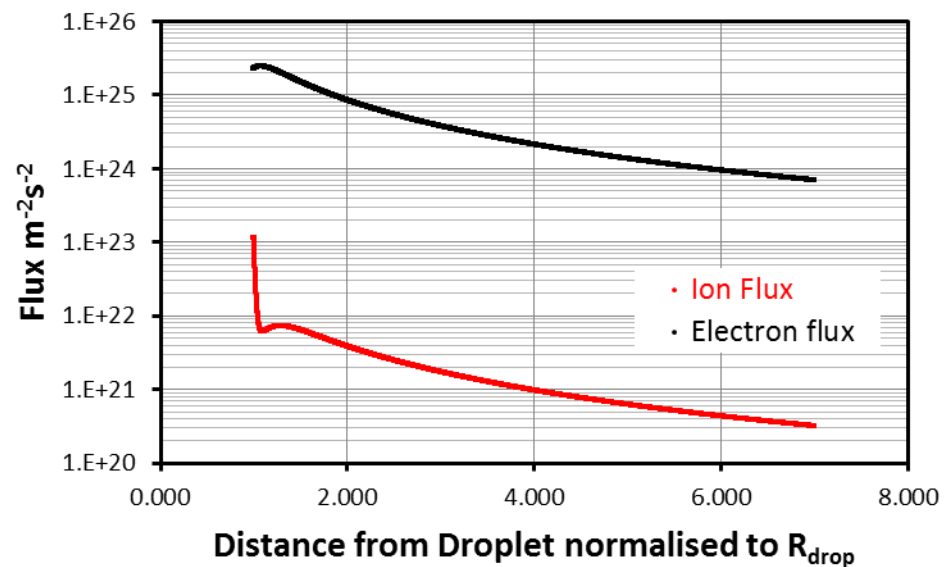
Input parameters

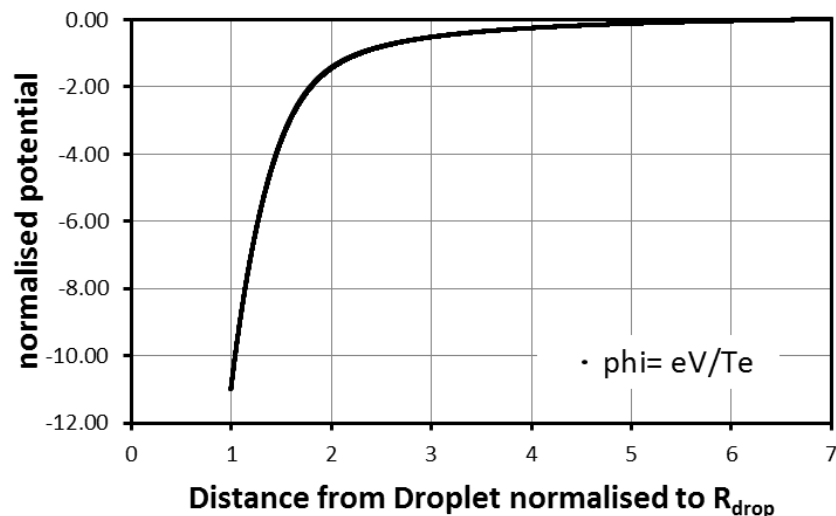
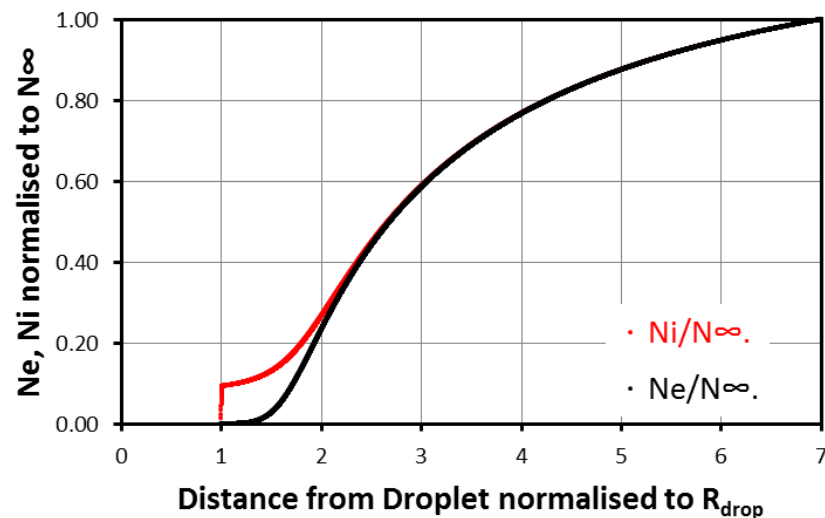
Small Q, low bias

$$Q_{\text{drop}} = 4 \times 10^5 e$$

$$T_e = 1 \text{ eV}$$

$$\phi = -1$$





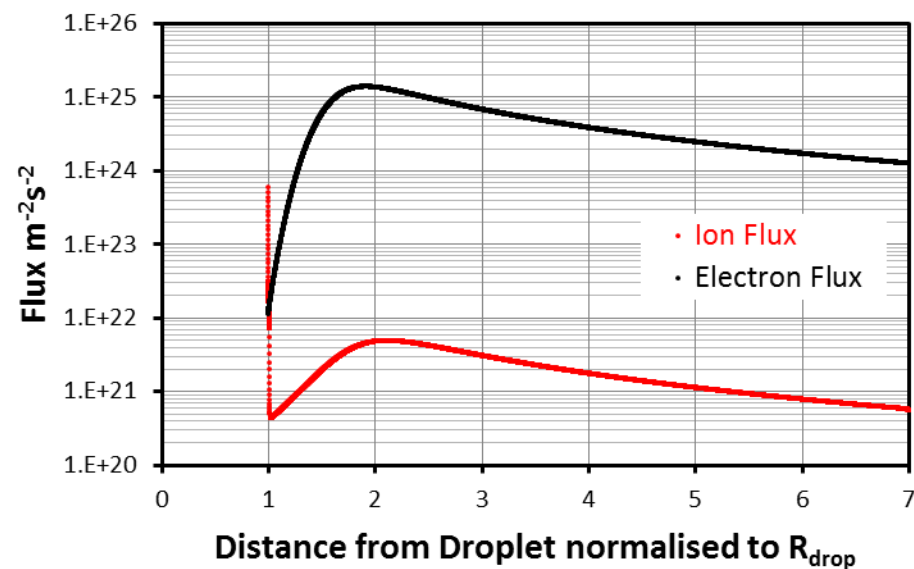
Input parameters

High Q, high bias

$$Q_{\text{drop}} = 5 \times 10^6 e$$

$$T_e = 1 \text{ eV}$$

$$\phi = -11$$





- Dusty plasma
 - ⇒ Low pressure
 - ⇒ Crystal, levitation
 - ⇒ 4500e for 10 μm particle
 - ⇒ Trottenberg et al. 1995
- Unipolar corona charging

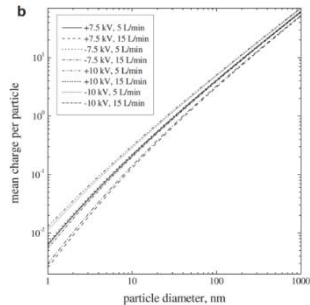


Fig. 8. Variation of mean charge per particle with particle diameter at different aerosol flow rate and applied voltage (a) 0 V and (b) 310 V.

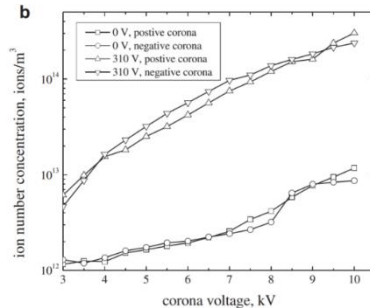


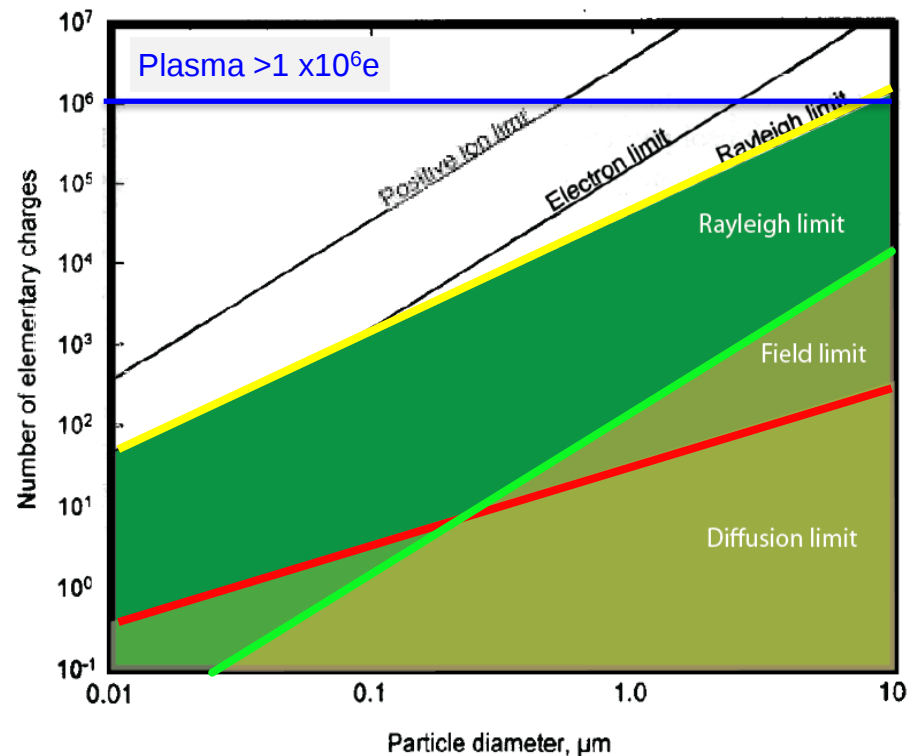
Fig. 9. Variations in ion number concentrations with corona voltage in the charge (a) discharge zone and (b) charging zone.

Corona discharge in a cylindrical triode charger for unipolar diffusion aerosol charging, P. Intra, J. Electrostat. **70** (2012) 136

Simulation: 10 μm particles,
 $Q_d = 7000$ (8 kV), 3000 (5kV)

Measured: 1 μm particles,
 $Q_d = 68$ (5kV)

Design of a unipolar aerosol charger to generate highly charged micron-sized aerosol particles. J Park et al., J. Electrostat. **69** (2011) 126



High electron density non-equilibrium
atmospheric pressure plasma
Unipolar charging
($T_e \gg T_{\text{gas}}$)
X 100 compared to other techniques
Close to Rayleigh limit



- $\times 10^3 - 10^7$ faster

⇒ Similar dose rate as gamma radiation

- Plasma-droplet

⇒ Dose rate assuming $x\%$ plasma energy delivered to drop according to ratio $VOL_{drop} / VOL_{plasma}$

⇒ $5 \times 10^{-2} \text{ kGy s}^{-1}$.

- Solvated Electron Reduction Hypothesis

⇒ Reactions: 2nd order

⇒ Droplet negatively charged

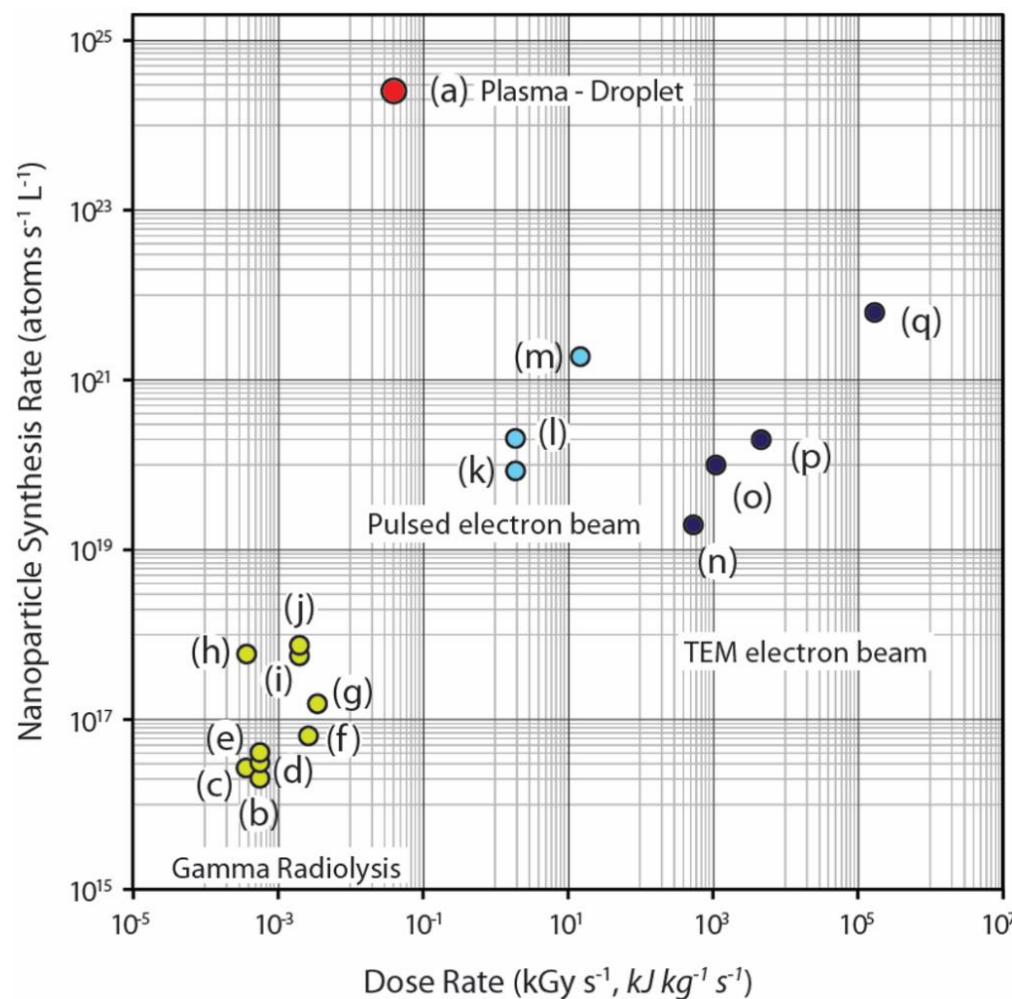
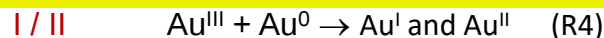
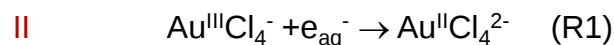
⇒ **Electrons arrive with very low energy**

⇒ **Electrostatically confined**

⇒ **shallow surface layer**

⇒ Very high local concentration

HAuCl_4 . The reduction of Au^{III} proceeds via reactions as:





Plasma induced liquid chemistry in droplet

Simulation



- Electron Flux to droplet

- ⇒ Collisional
- ⇒ $D \gg \lambda_i$, $D \gg \lambda_{De}$
- ⇒ No analytical solution

- Ion Flux to droplet

- ⇒ No analytical solution
- ⇒ Collisional
- ⇒ Very low energy

- Ion type

- ⇒ Water product ions
- ⇒ Noble gas ions
- ⇒ Ratio water/noble ions: important

- Flux induced droplet chemistry

- ⇒ Charge and chemical species flux to droplet

- Model (liquid)

- ⇒ Plasma induced chemistry
- ⇒ In liquid
- ⇒ 1D radial
- ⇒ 15 species, including solvated electrons
- ⇒ 100 reactions

- Charge flux (variable n_e)

- Neutral chemical flux

- ⇒ OH, H, H₂O₂, H₂, O₂.

- H₂O → H₂O₂ conversion efficiency

- ⇒ Literature, up to 6000ppm
- ⇒ Across plasma types and conditions
- ⇒ $Y_{H_2O_2} \sim 10^{-3}$, from gas phase measurements
- ⇒ $Y_{H_2O_2} \sim 10^{-4}$, from liquid measurements

- H₂O → OH, H conversion efficiency

- ⇒ OH + OH → H₂O₂.
- ⇒ but some show $N_{OH} \sim N_{H_2O_2}$



Diameter
15 μm , 20 μm

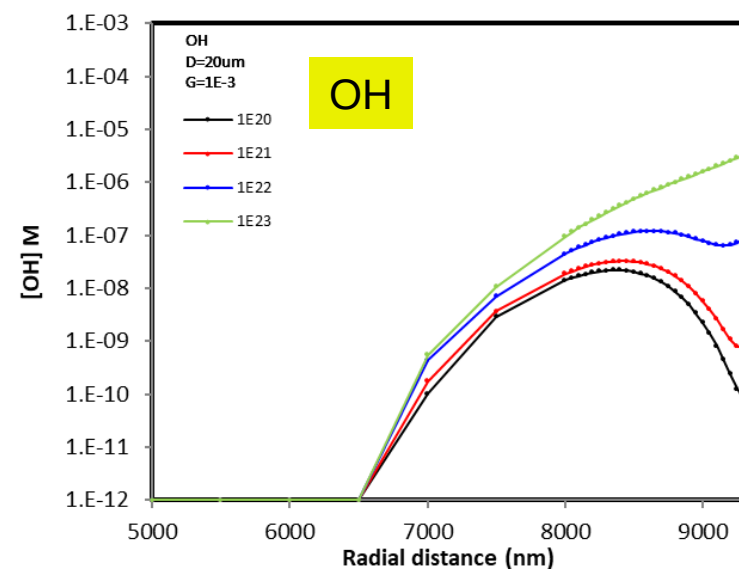
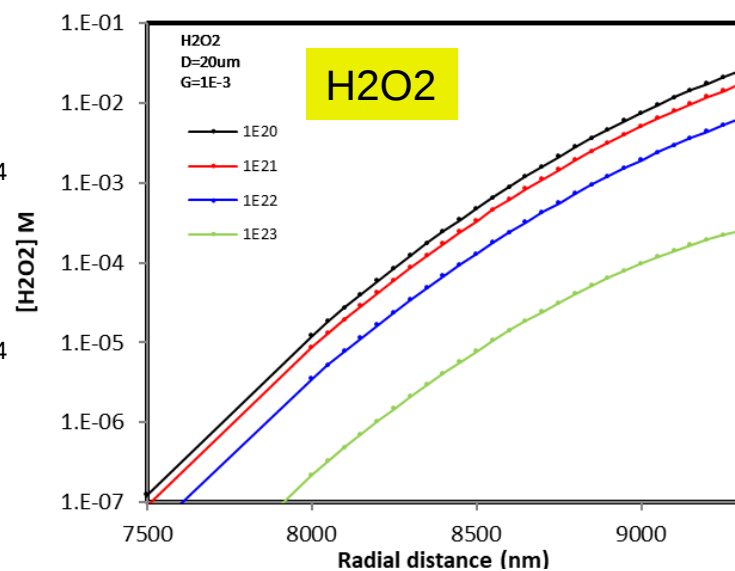
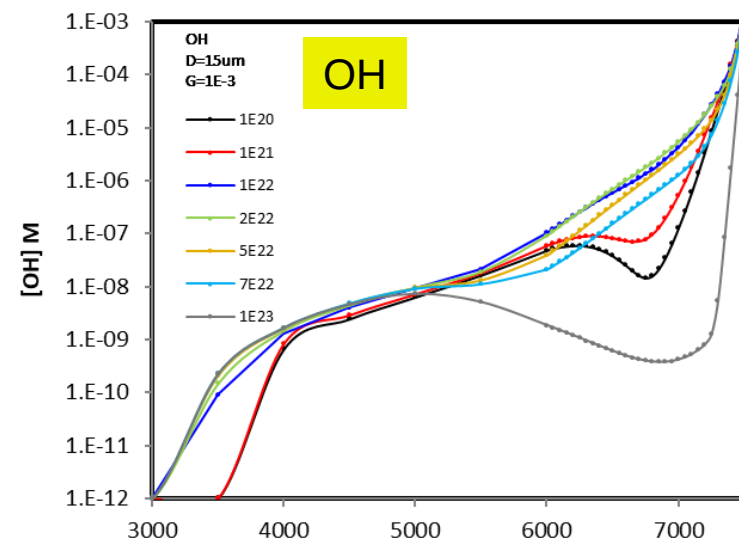
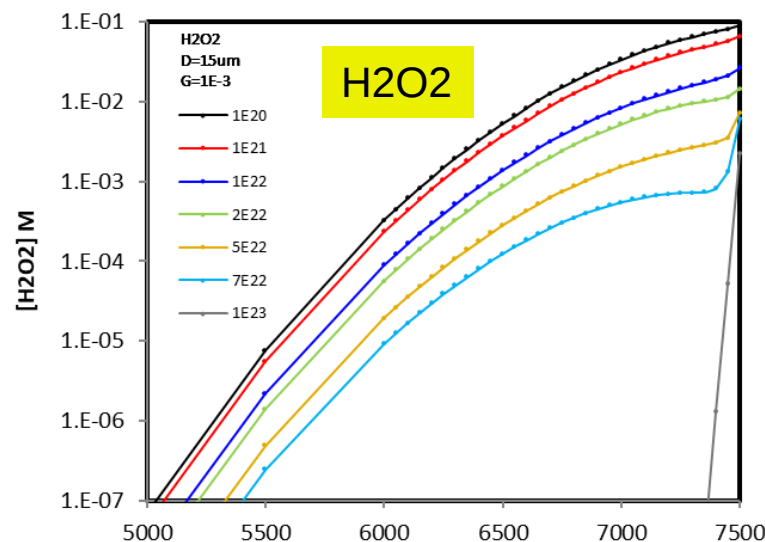
Electron flux:
 $10^{20} - 10^{23} \text{ m}^{-2} \text{ s}^{-1}$

H_2O_2 :
Decreases with increasing electron flux

OH:
Optimum flux at $10^{22} \text{ m}^{-2} \text{ s}^{-1}$.

15 μm : 1mM max conc. Decays by 10^{-4} over 1500nm

20 μm : 1 μM max conc. Decays by 10^{-4} over 2500nm





Diameter
15um, 20um

Electron flux:
 $10^{20} - 10^{23} \text{ m}^{-2} \text{ s}^{-1}$

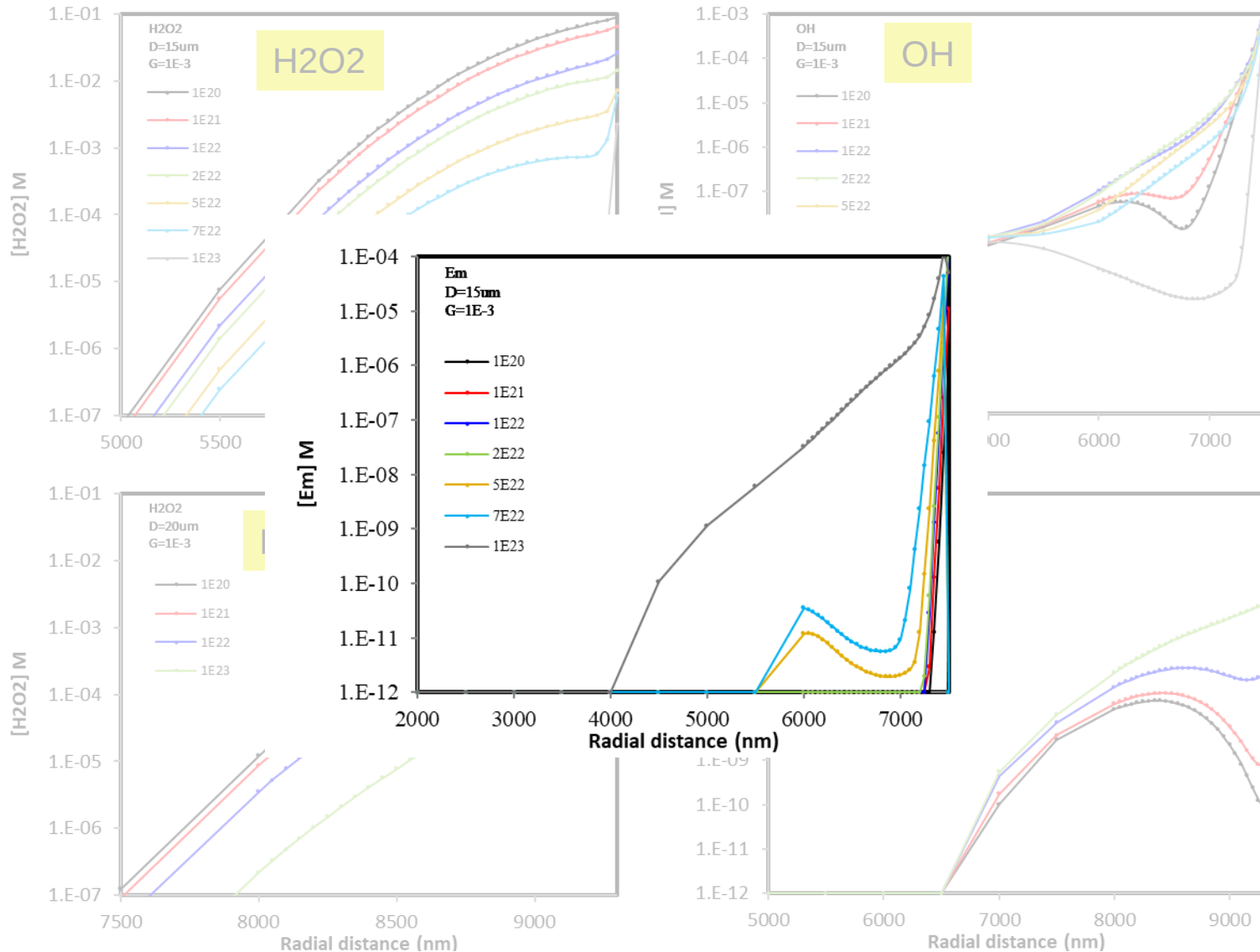
H₂O₂:
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increasing electron
flux

OH:
Optimum flux
at $10^{22} \text{ m}^{-2} \text{ s}^{-1}$.

15um: 1mM max
conc. Decays by 10^{-4}
over 1500nm

20um: 1μM max
conc. Decays by 10^{-4}
over 2500nm

Solvated electrons
- No electric field in
model



Droplet temperature dependent Henry's constant for OH and H2O2



Some scientific questions



• Electron solvation layer

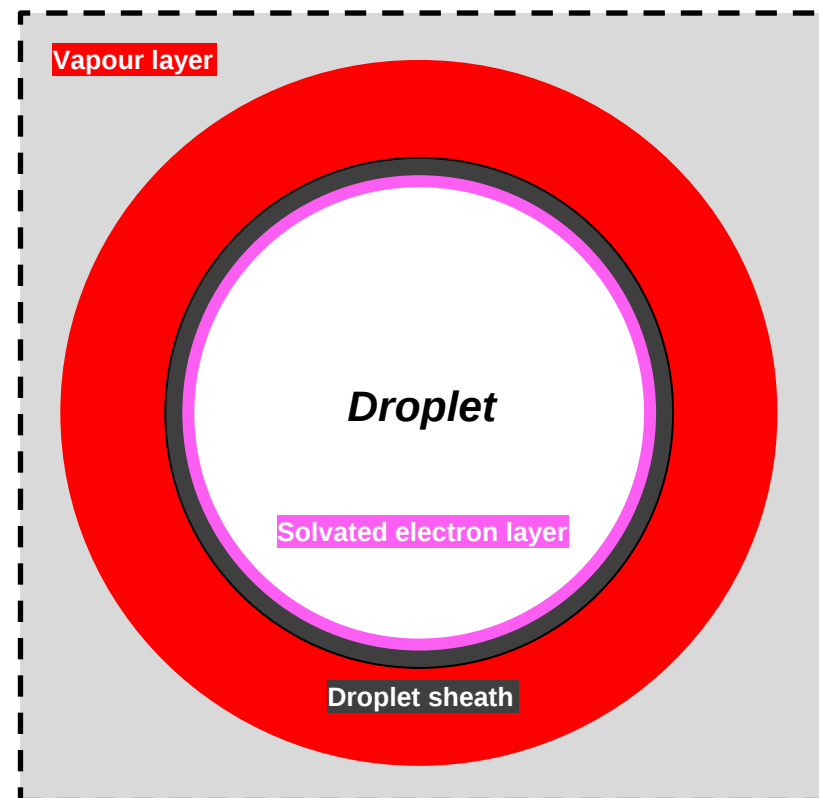
- ⇒ Charge: 10^6 electrons: 10 - 20 μm sphere
- ⇒ Assume solvation
- ⇒ Steady-state, during plasma residence, 100 μs .
- ⇒ Unlike radiolysis (transient spurs)

• Estimates from plasma - bulk liquid

- ⇒ Rumbach et al., *Nature Comms* **6**, 7248 (2015) Planar plasma – bulk liquid studies:
- ⇒ Solvated electron concentration – approaching **1 mM**. *Estimate*.
- ⇒ Electron penetration depth **10 nm**

• Surface water structure

- ⇒ Water structure with such a high concentration of solvated electrons?
- Solvation cage: solvated electron surrounded by tetrahedral 4x H_2O molecules.





- **Charged droplet**

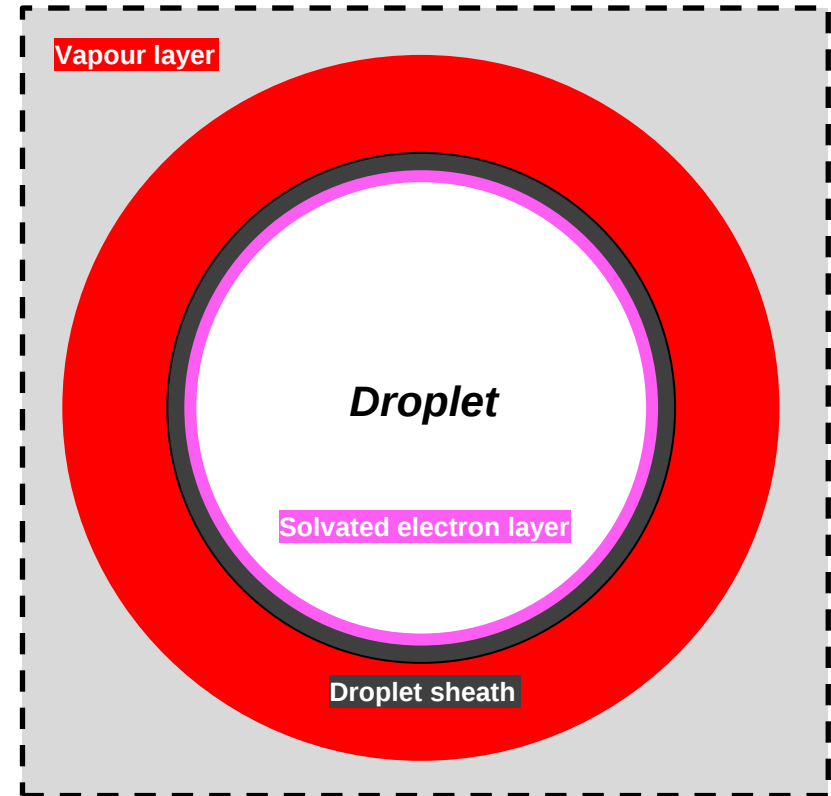
- ⇒ Surface layer of solvated electrons

- **Electric field**

- ⇒ Internal electric field, will develop over time
- ⇒ **Dielectric relaxation**
- ⇒ Dielectric relaxation time ~ 50 ms for $15 \mu\text{m}$ droplet ($\tau_d = \epsilon / en\mu$)
- ⇒ Plasma residence time: $100 \mu\text{s}$.
- ⇒ **Ion drift**
- ⇒ Mobile ion drift (H^+ , OH^- from pH).
- ⇒ The H^+ diffusion constant is $9 \times 10^{-9} \text{ m}^2\text{s}^{-1}$ and the time taken to traverse the droplet from centre is ~ 6 ms.

- **Chemical reactions**

- ⇒ electron initiated
- ⇒ pH gradient
- ⇒ ion recombination



⇒



- **Charged droplet**

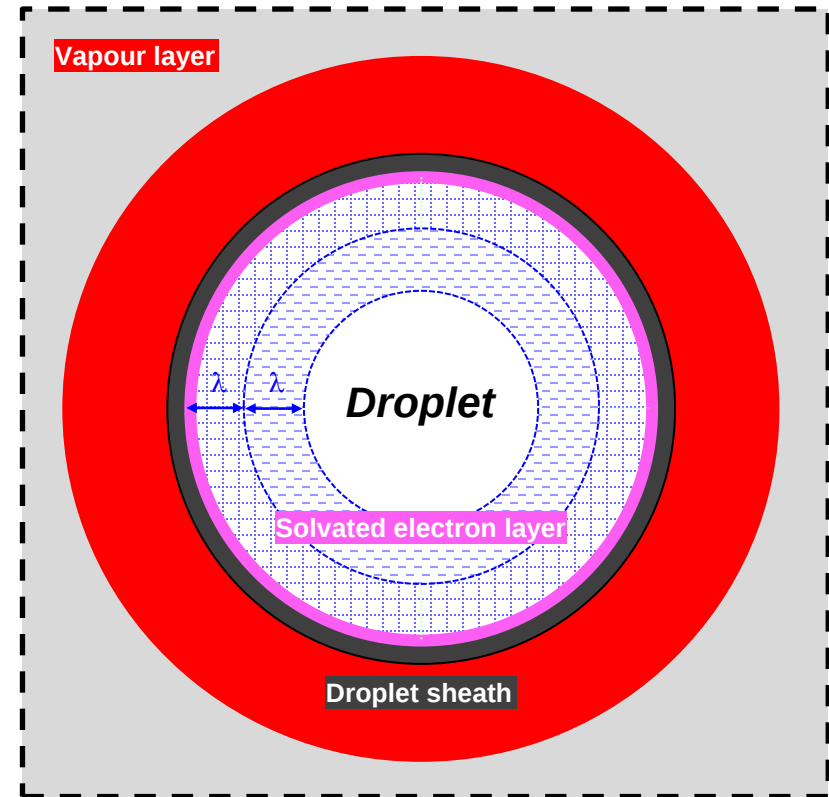
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- **Charge separation**

- ⇒ DI water ($\text{pH} = 7$), total number of H^+ ions in a $15 \mu\text{m}$ diameter droplet is $\sim 10^5$
- ⇒ Similar to surface charge magnitude.
- ⇒ If all the H^+ ions collect within λ of the surface, to screen negative surface charge
- ⇒ All OH^- is displaced to within region λ to 2λ where $2\lambda < R$,
- ⇒ Core region ($0 \rightarrow R - 2\lambda$) is depleted of ions .





Charged droplet

- Surface layer of solvated electrons

Charge separation

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Debye-Huckel Theory

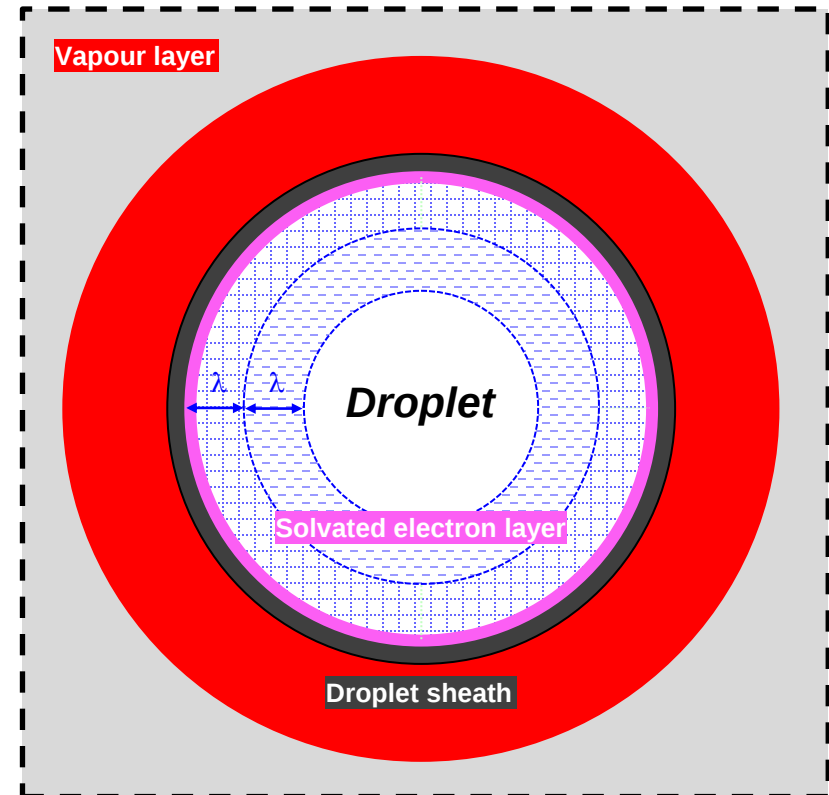
- Surface electron charge attracts H^+ into Debye layer λ_1 and repels OH^- into Debye layer λ_2 . λ is Debye screen length given by

$$\lambda^2 = \frac{\epsilon k_B T}{e^2 n}$$

- n is the charge density. Total net charge within mantle is equal to $-Q_s$, the surface charge.

Model simulation

- Debye-Huckel assumes linear Poisson-Boltzmann ie. $V \sim kT/e$.
- However estimated droplet potential: - 10V



Problem

Full exponential Poisson-Boltzmann equation required. Problem for simulation.

$$n(r) = n_0 e^{+\frac{e(\phi(r)-\phi_0)}{kT}}$$

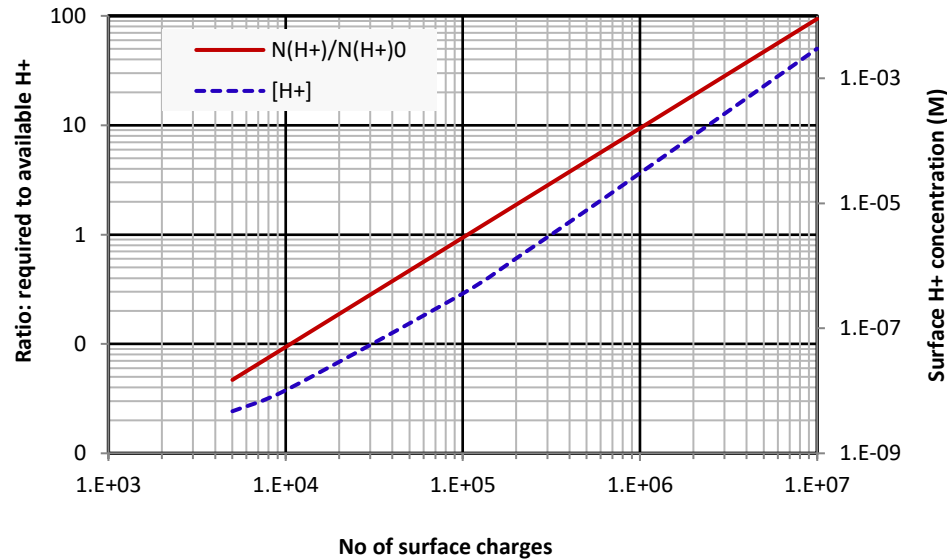
$$p(r) = p_0 e^{-\frac{e(\phi(r)-\phi_0)}{kT}}$$



Debye-Huckel Theory

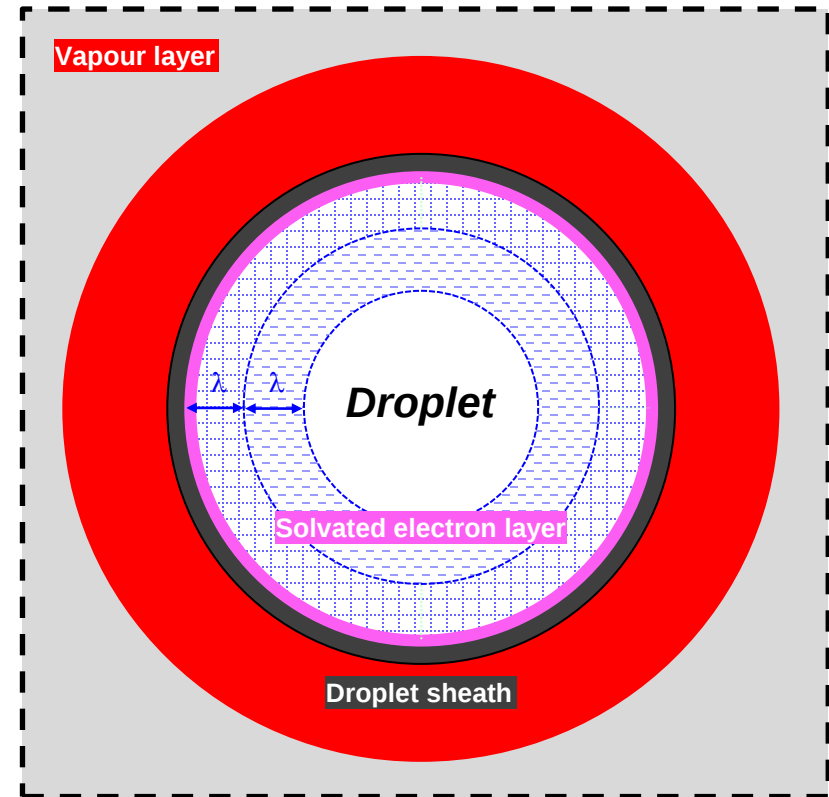
- Surface electron charge
- attracts H^+ into Debye layer λ_1 and
- repels OH^- into Debye layer λ_2 .

$$\lambda^2 = \frac{\epsilon k_B T}{e^2 n}$$



Red curve: ratio of $N_{H^+}^*$ (no of H^+ molecules required to screen surface charge Q_s) to N_{H^+} (no of H^+ molecules available)

Blue curve: N_{H^+} (no of H^+ molecules available)



For $Q_s > 10^5 e$, $N_{H^+}^*/N_{H^+} > 1$

Enhanced dissociation constant (K_a)

- presumably further self-ionisation occurs in central region i.e. the average dissociation of water in the droplet is increased due to the charged surface.



- Solvation Energy Barrier

- ⇒ Does an energy barrier exist to electron adsorption and solvation?
- ⇒ What is the electron arrival energy?

- Electron solvation

- ⇒ excess electron in free mobile state in the solvent conduction band
- ⇒ transfers from to spatially localised state: trapped in potential well, formed by configurational changes induced by the electron itself.
- ⇒ electrons can exist in localised as well as extended (delocalised) states.

- Electron states

- ⇒ lowest energy **extended** state is the bottom of the liquid conduction band, normally empty in a liquid.
- ⇒ trapped state A: pre-solvated electron - may occur at a broken hydrogen bond site.
- ⇒ trapped state B: solvated electron – tetrahedral water cage arrangement
- ⇒ simplest model: free scattering electron is trapped in a pre-solvated state, in less than a picosecond, and finally solvated upon relaxation of the solvent.



- Solvation Energy Barrier

- ⇒ Does an energy barrier exist to electron adsorption and solvation?
- ⇒ What is the electron arrival energy?

- Continuum dielectric model of solvated electrons

- ⇒ solvated electron treated as a point charge at centre of a spherical cavity i.e. bound within a dielectric medium
- ⇒ trapped in the potential well formed by the polar solvent environment –
- ⇒ one O – H from each of 4 x H₂O molecules is hydrogen-bonded to the electron.
- ⇒ Born equation: solvation energy for charged species, represents work done transferring charge from gas to liquid
- ⇒ equivalent to the electrostatic energy required to charge a sphere in the liquid, with dielectric constant ϵ_r , relative to that required to discharge an ion in the gas.
- ⇒ more accurately: work required to polarise dielectric cavity after electron has been transferred.
- ⇒ the process of solvation results in heat release.
- ⇒ large electron solvation energy of -156 kJ mol^{-1} (or 1.617 eV per electron)

- Relaxation time

- ⇒ Solvent reorganisation, equilibrium $\rightarrow$ non-equilibrium state
- ⇒ Local equilibrium assumed – for theory



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- ⇒ Local equilibrium assumed – for theory

- Vertical Detachment (or Binding) Energy (VDE or VBE)

- ⇒ cluster models
- ⇒ **Solvent Reorganization Energy (SRE)**: the difference in solvation free energy between nonequilibrium and equilibrium polarizations. Depends on optical permittivity.
- ⇒ **Adiabatic Electron Binding Energy (AEBE)**: difference in equilibrium solvation free energy for neutral and negatively charged cluster - depends on permittivity ϵ_r , cavity radius, cluster size.
- ⇒ extrapolate for bulk water, infinite cluster size.
- ⇒ VDE (water): **3.12 eV** (calculated)
- ⇒ VDE (large clusters): **3.3 eV** (experimental)
- ⇒ VDE (water droplets): **3.7 eV** (experimental)



ARTICLES

PUBLISHED ONLINE: 7 MARCH 2010 | DOI: 10.1038/NCHEM.580

nature
chemistry

Binding energies, lifetimes and implications of bulk and interface solvated electrons in water

Katrin R. Siefermann¹, Yaxing Liu¹, Evgeny Lugovoy², Oliver Link¹, Manfred Faubel³, Udo Buck³,

• Solvation Energy Barrier

- ⇒ Does an energy barrier exist to electron adsorption?
- ⇒ What is the electron arrival energy?

• VDE

- ⇒ VDE (water): **3.12 eV** (calculated)
- ⇒ VDE (large clusters): **3.3 eV** (experimental), VDE (water droplets): **3.7 eV** (experimental)

• Experimental evidence

- ⇒ Siefermann et al.
- ⇒ Liquid jet photoelectron spectroscopy (PES)
- ⇒ measured VDE of surface partially solvated electrons: **1.6 eV**.
- ⇒ similar to VDE of amorphous solid water (1.4 eV).
- ⇒ penetration depth: **less than one monolayer**
- ⇒ significant free-energy barrier may exist between surface and bulk solvation
- ⇒ due to molecular reorientation of surface water mediated by surface-bound electrons preventing penetration of surface electrons into the bulk.
- ⇒ free-energy barrier height estimate ~ **0.2 eV – 0.5 eV**.

• Simulations

- ⇒ simulations have been unable to find such a barrier
- ⇒ capability of PES to distinguish interfacial from bulk electrons is questioned.



- Solvation Energy Barrier

- ⇒ Does an energy barrier exist to electron adsorption and solvation?
- ⇒ What is the electron arrival energy?

- VDE

- ⇒ VDE (water): **3.12 eV** (calculated)
- ⇒ VDE (large clusters): **3.3 eV** (experimental),
- ⇒ VDE (water droplets): **3.7 eV** (experimental)

- Experimental evidence

- ⇒ measured VDE of surface partially-solvated electrons: **1.6 eV**.
- ⇒ penetration depth: **less than one monolayer**
- ⇒ free-energy barrier height estimate $\sim 0.2 \text{ eV} - 0.5 \text{ eV}$.

- Electron net arrival energy at droplet

- ⇒ when droplet at floating potential, ϕ .
- ⇒ only electrons with $E > \phi$ will reach droplet.
- ⇒ from EEDF, $n_e(E > \phi) \cong n_e(E = \phi + \Delta\phi)$
- ⇒ net arrival energy $\Delta\phi \sim 0$
- ⇒ **lower than estimated solvation barrier height.**



- Solvation Energy Barrier
 - ⇒ Does an energy barrier exist to electron adsorption and solvation?
 - ⇒ What is the electron arrival energy?
- Experimental evidence
 - ⇒ penetration depth: **less than one monolayer**
 - ⇒ free-energy barrier height estimate **~ 0.2 eV – 0.5 eV.**
- Electron net arrival energy at droplet
 - ⇒ net arrival energy $\Delta\phi \sim 0$
 - ⇒ **lower than estimated solvation barrier height.**
- Estimates from plasma - bulk liquid
 - ⇒ *Rumbach et al., Nature Comms 6, 7248 (2015)* Planar plasma – bulk liquid studies:
 - ⇒ Solvated electron concentration – approaching **1 mM**. *Estimate.*
 - ⇒ Electron penetration depth **10 nm**
 - ⇒ **Electron arrival energy:** sheath electric field, sheath width vs mean free path, collisions
 - ⇒ Ion energy simulations with collisions: 6 – 10 eV (DBD or single filaments) [Babaeva 2012](#), 2 – 3 eV (APPJ) [Babaeva 2020](#), < 1 eV (90%), 1 – 8 eV (10%) (DC microplasma) [Choi 2007](#), 5 – 12 eV [Gopalakrishnan 2016](#)



- Solvation Energy Barrier
 - ⇒ Does an energy barrier exist to electron adsorption and solvation?
 - ⇒ What is the electron arrival energy?
- Experimental evidence
 - ⇒ penetration depth: **less than one monolayer**
 - ⇒ free-energy barrier height estimate ~ **0.2 eV – 0.5 eV.**
- Electron net arrival energy at droplet
 - ⇒ net arrival energy $\Delta\phi \sim 0$
 - ⇒ **lower than estimated solvation barrier height.**
- Solvated electron monolayer
 - ⇒ Q = Rayleigh charge
 - ⇒ Minimum electron – electron distance: **10 nm**
 - ⇒ Solvation cavity diameter / gyration diameter: **0.5 nm**
 - ⇒ Concentration: up to **20 mM**
 - ⇒ $e_{aq}^- + e_{aq}^- + 2H_2O \rightarrow H_2 + 2OH^-$ (R1)



- $\times 10^3 - 10^7$ faster

⇒ Similar dose rate as gamma radiation

- Plasma-droplet

⇒ Dose rate assuming $x\%$ plasma energy delivered to drop according to ratio $VOL_{drop} / VOL_{plasma}$

⇒ $5 \times 10^{-2} \text{ kGy s}^{-1}$.

- Solvated Electron Reduction Hypothesis

⇒ Reactions: 2nd order

⇒ Droplet negatively charged

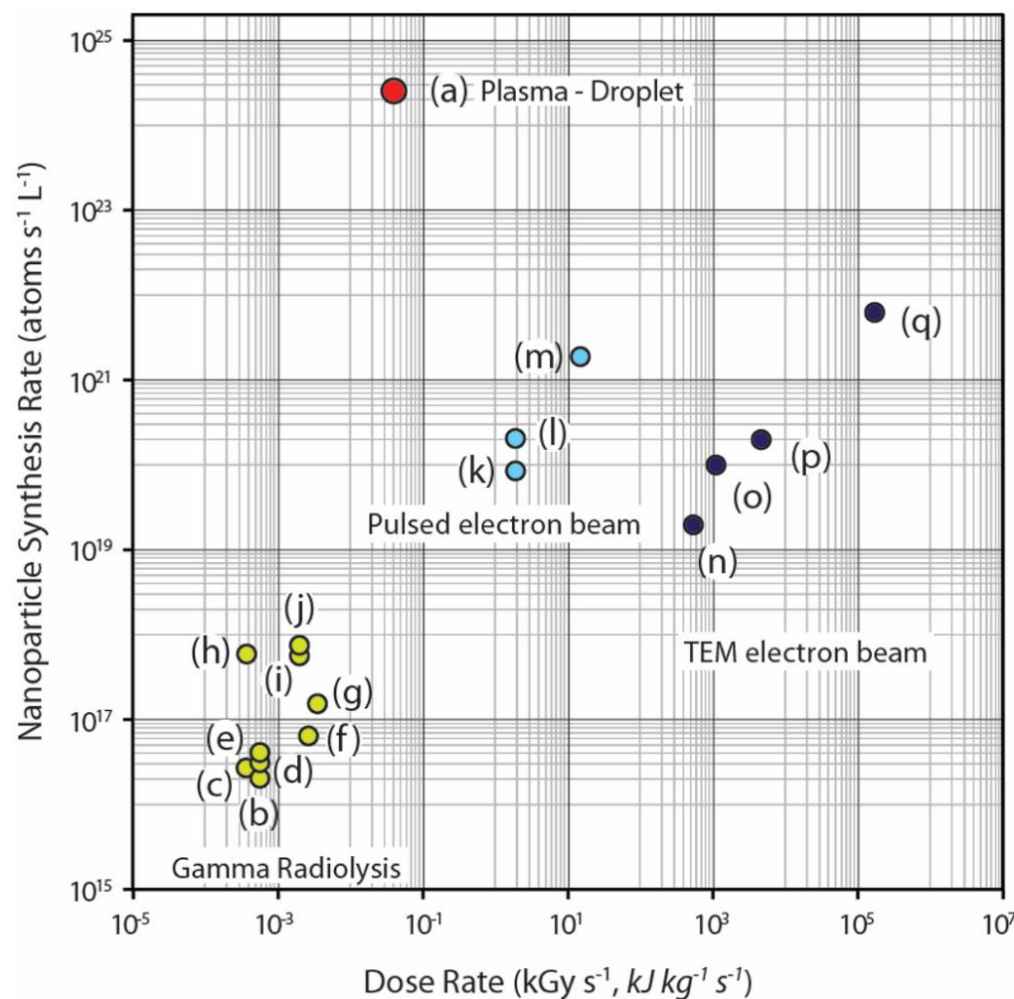
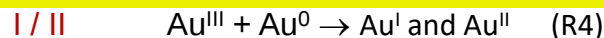
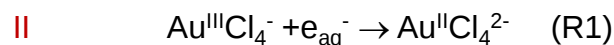
⇒ **Electrons arrive with very low energy**

⇒ **Electrostatically confined**

⇒ **shallow surface layer**

⇒ Very high local concentration

HAuCl_4 . The reduction of **Au^{III}** proceeds via reactions as:



Funding Sources



The Leverhulme Trust



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SfP 984555



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